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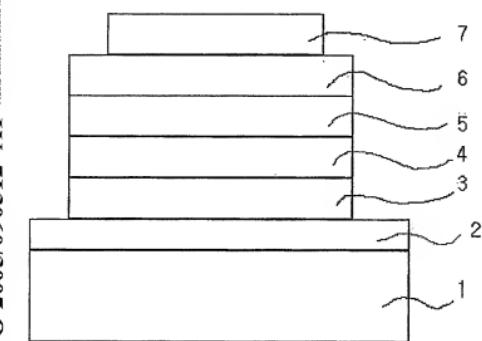
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[Continued on next page]

(54) Title: NEW MATERIALS FOR INJECTING OR TRANSPORTING HOLES AND ORGANIC ELECTROLUMINESCENCE DEVICES USING THE SAME



(57) Abstract: The present invention relates to a novel compound that can significantly improve the lifespan, efficiency and thermal stability of an organic light emitting device, and to an organic electroluminescence device or light emitting device comprising the compound in an organic compound layer is also disclosed.



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NEW MATERIALS FOR INJECTING OR TRANSPORTING HOLES AND
ORGANIC ELECTROLUMINESCENCE DEVICES USING THE SAME

Technical Field

5 The present invention relates to a novel compound that can greatly improve lifespan, efficiency and thermal stability of organic light emitting devices, and to an organic light emitting device comprising the same compound in an organic compound layer.

10

Background Art

In the era of advanced information technology of the 21st century, a great deal of information should be obtained promptly with ease, and thus an importance of 15 the high performance flat panel display for multimedia increases. Although liquid crystal displays (LCDs) have played the main part of flat panel displays up to now, many attempts are made to develop novel flat panel displays that are cost-efficient, show excellent 20 performance and are differentiated from liquid crystal displays all over the world. Organic electroluminescence (EL) devices or organic light emitting devices that are expected to play an important role as advanced flat panel displays have advantages of lower drive voltage, 25 higher response rate, higher efficiency and wider view angle, compared to liquid crystal displays. In addition, because displays using organic electroluminescence phenomenon permit a total module thickness of 2 mm or less and can be manufactured on plastic substrates 30 having a thickness of 0.3 mm or less, it is possible to meet the trend of thinning and downsizing of displays. Moreover, organic electroluminescence displays have an

additional advantage in that they are produced at a lower cost compared to liquid crystal displays.

Organic light emitting devices are based on the mechanism wherein electrons and holes injected to an 5 organic film formed of organic compounds through an anode and a cathode form exitons when they are recombined and then light having a certain wavelength is emitted from the exitons. In 1965, Pope et al. found electroluminescence in an anthracene single crystal for 10 the first time. Following this, in 1987, Tang et al. in Kodak Co. found that an organic light emitting device formed of organic materials with a structure having separate functional laminated layers, i.e., a hole transport layer and light emitting layer laminated to 15 each other, can provide a high luminance of 1000 cd/m² or higher even under a low voltage of 10V or less. After those findings, organic light emitting devices has been a matter of great interest in the field of display technology (Tang, C.W.; Vanslyke, S. A. *Appl. Phys. Lett.* 1987, 51, 913). Such organic light emitting 20 devices are classified into those using fluorescence and those using phosphorescence capable of providing a high efficiency of up to three times of the fluorescence-based efficiency. Alternatively, such organic light 25 emitting devices may be classified according to molecular weights of the organic materials forming organic light emitting devices, i.e., those prepared by a low-molecular weight method wherein a device is formed by using a vacuum sublimation process and those prepared 30 by a high-molecular weight method wherein a device is formed by using solution processes such as a spin coating, ink jet printing or roll coating process.

As shown in FIG. 1, a conventional organic light emitting device includes an anode, a hole injection layer that accepts holes from the anode, a hole transport layer that transports holes, a light emitting layer in which holes and electrons are recombined to emit light, an electron transport layer that accepts electrons from a cathode and transport them to the light emitting layer, and a cathode. The above thin film layers are formed by a vacuum deposition process. The 10 reason for manufacturing organic light emitting devices having a multilayered thin film structure is as follows. It is possible to transport holes and electrons to a light emitting layer more efficiently when a suitable hole transport layer and electron transport layer are 15 used, because the moving rate of holes is significantly higher than that of electrons in organic materials. Additionally, it is possible to increase luminous efficiency when hole density is balanced with electron density in a light emitting layer.

20 Hereinafter, a conventional organic light emitting device will be explained referring to FIG. 1.

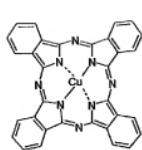
25 A substrate 1 is the support for an organic light emitting device and may be formed of a silicone wafer, quartz or glass plate, metal plate, plastic film or sheet, etc. Preferably, glass plates or transparent plates made of synthetic resins such as polyester, polymethacrylate or polysulfone are used.

30 A first electrode (anode) 2 is disposed on the substrate 1. The anode serves to inject holes to a hole injection layer 3 and may be formed of metals such as aluminum, gold, silver, nickel, palladium or platinum, metal oxides such as indium-tin oxides or indium-zinc

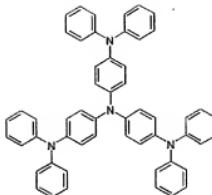
oxides, halogenated metals, carbon black, or conductive polymers such as poly(3-methylthiophene), polypyrrole or polyaniline.

The hole injection layer 3 is disposed on the anode 2. Materials used in the hole injection layer have to provide high efficiency of hole injection from the anode and have to transport the injected holes efficiently. In this regard, the materials should have low ionization potential, high transparency to visible light and excellent stability to holes.

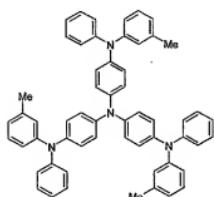
Materials for the hole injection layer include compounds that have excellent thermal stability while maintaining a stable interface with the anode. Typical examples of the materials include copper phthalocyanine (CuPc), which is a porphyrin-copper complex disclosed in US Patent No. 4,356,429 by Kodak, Co. Because CuPc is the most stable compound for use in a hole injection layer, it has been used widely. However, it shows an absorption band at the blue and red zones, and thus has problems when manufacturing full-color display devices. Recently, starburst-like aromatic aryl amine compounds having no absorption band at the blue zone are known (US Patent No. 5,256,945 and Japanese Laid-Open Patent No. 1999-219788, and see the following formulae 4-12). Particularly, among the starburst-like amines having no absorption band at the blue zone, compounds represented by the following formulae 8-12 having a glass transition temperature of 100°C or higher and excellent stability are used.



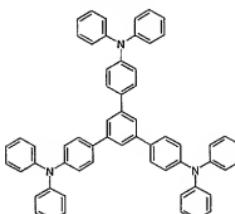
CuPc



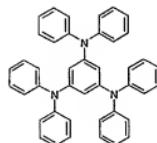
formula 4



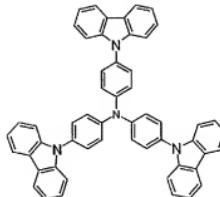
formula 5



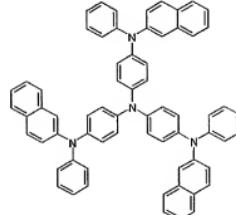
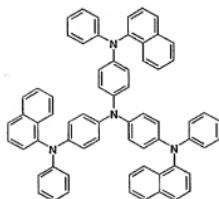
formula 6



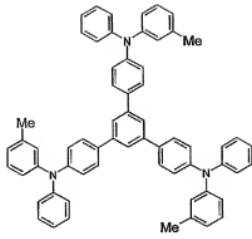
formula 7



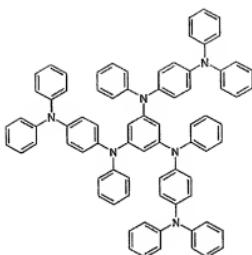
formula 8



formula 9



formula 10

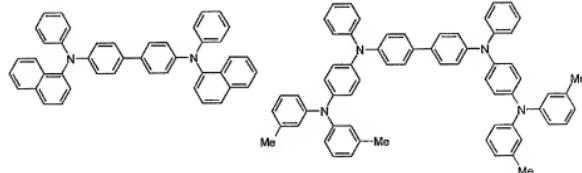


formula 11

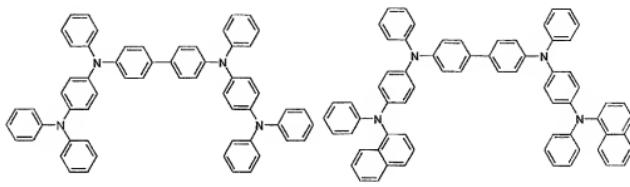
formula 12

5 Recently, many hole injection materials having a higher glass transition temperature and more improved thermal stability have been reported. Most of them are compounds derived from NPB of Kodak, Co. and are represented by the following formulae 13-17 (see,
10 11 Japanese Laid-Open Patent No. Hei9-301934 and US Patent Nos. 6,334,283 and 6,541,129).

NPB

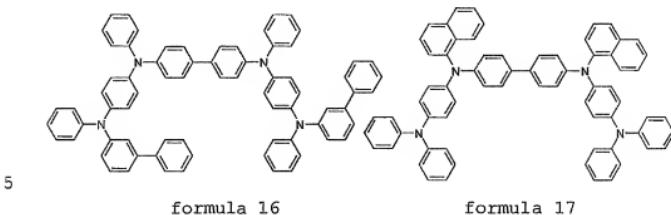


formula 13



formula 14

formula 15

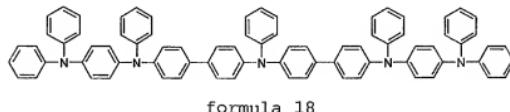


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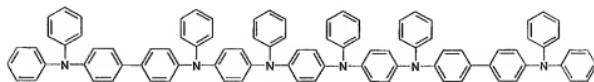
formula 16

formula 17

Additionally, Japanese Laid-Open Patent No. 2003-238501 discloses aromatic oligoamine derivatives having at least five nitrogen atoms in one molecule (formulae 18 and 19).



formula 18



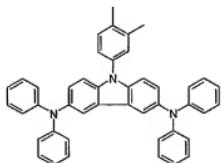
15

formula 19

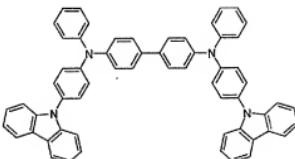
Further, more recently, Japanese Laid-Open Patent

No. 2003-317966 and US Patent No. 6,660,410 disclose a carbazole group-containing material (formula 20), which is specifically used as host forming a light emitting layer in an organic light emitting device using phosphorescence and is claimed to improve the lifespan of an organic light emitting device compared to conventionally known CBP (carbazole biphenyl). Other compounds used in a hole injection layer are represented by the following formulae 21-27.

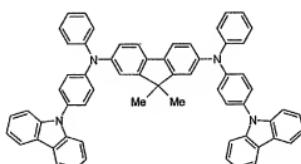
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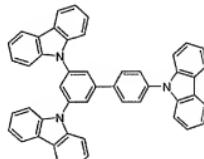
formula 20



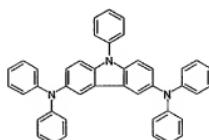
formula 21



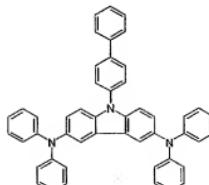
formula 22



formula 23

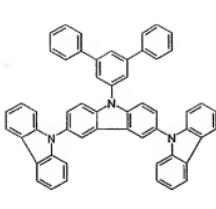


formula 24

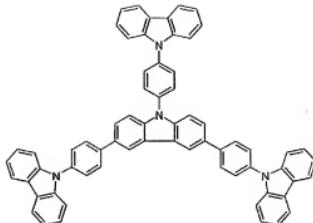


formula 25

15



formula 26



formula 27

A hole transport layer 4 is disposed on the hole injection layer 3. The hole transport layer serves to accept holes from the hole injection layer and transport them to an organic light emitting layer 5 disposed thereon. The hole transport layer has high hole transportability and stability to holes. It also serves 10 as a barrier to protect electrons. In addition to the above-mentioned basic requirements, when it is used in display devices for cars, for example, it is preferable that the materials for a hole transport layer have an improved heat resistance and a glass transition 15 temperature(T_g) of 80°C or higher. Materials satisfying such requirements include NPB, spiro-arylamine compounds, perylene-arylamine compounds, azacycloheptatriene compounds, bis(diphenylvinylphenyl)anthracene, silicon germanium oxide compounds, silicon-containing arylamine compounds, or the like.

Meanwhile, as an important organic single molecules for a hole transport layer, there is arylamine compounds having high hole transport rate and excellent electrical stability. In order to improve thermal 25 stability of arylamine compounds, hole transport

materials into which a naphthyl substituent or spiro group is introduced are reported (see, US Patent Nos. 5,554,459 and 5,840,217). In the beginning, N,N'-diphenyl-N,N'-bis(3-methylphenyl)-1,1'-diphenyl-4,4'-diamine (TPD) is frequently used as organic hole transport material. However, because TPD is unstable at a temperature of 60°C or higher, N-naphthyl-N-phenyl-1,1'-diphenyl-4,4'-diamine (NPD) based materials or amine compounds substituted with a greater number of aromatic groups that have a higher glass transition temperature are used at the present time. Particularly, organic single molecules for use in a hole transport layer should have high hole transport rate. Additionally, because a hole transport layer is in contact with a light emitting layer and forms an interface therebetween, organic single materials for a hole transport layer should have an adequate ionization potential value of between that of a hole injection layer and that of a light emitting layer so as to inhibit the generation of exitons at the interface between hole transport layer and light emitting layer. Further, the organic single materials for a hole transport layer are required to control the electrons transported from the light emitting layer.

An organic light emitting layer 5 is disposed on the hole transport layer 4. The organic light emitting layer, which serves to emit lights by the recombination of holes and electrons injected from the anode and cathode, respectively, is formed of materials having high quantum efficiency.

Organic single molecules for use in a light emitting layer where light emission is accomplished by

the recombination of holes and electrons are classified functionally into host materials and guest materials. In general, host materials or guest materials can accomplish light emission when used alone. However, host 5 materials are doped with guest materials in order to solve the problems of low efficiency and luminance and the problem of self-packing of the same molecules that causes the excimer characteristics to come out in addition to the unique characteristics of each molecule.

10 More particularly, as green light emitting layer, 8-hydroxyquinoline aluminum salt (Alq3) is uniquely used and may be doped with high-quantum efficiency materials such as quinacridone or C545t so as to increase luminous efficiency. Organic materials for a blue light emitting 15 layer have problems in that they have low melting points and low luminous stability at the initial time and that they have poor lifespan, compared to Alq3 as green light emitting material. Additionally, because most materials for a blue light emitting layer represent a light blue 20 color rather than pure blue color, they are not suitable for full-color version displays, and so, they are also doped with perylene or distryl amines (DSA) to increase luminous efficiency. Typical organic materials for a blue light emitting layer include aromatic hydrocarbons, 25 spiro-type compounds, aluminum-containing organometallic compounds, heterocyclic compounds having an imidazole group, fused aromatic compounds, as disclosed in US Patent Nos. 5,516,577, 5,366,811, 5,840,217, 5,150,006 and 5,645,948. Meanwhile, in the case of a red light 30 emitting layer, a large amount of green light emitting material doped with a small amount of red light emitting material is used due to the characteristically narrow

band gap of red light emission. However, such materials have structural problems disturbing the improvement of lifespan.

An electron transport layer 6 is disposed on the 5 organic light emitting layer 5. In the electron transport layer 6, such materials as having high electron injection efficiency from a cathode 7 (a second electrode) and capable of transporting the injected electrons efficiently are used. For satisfying this, the 10 materials should have high electron affinity and electron moving rate and excellent stability to electrons. Materials that meet the above requirements include: aromatic compounds such as tetraphenylbutadiene (Japanese Laid-Open Patent No. Sho57-51781), metal 15 complexes such as 8-hydroxyquinoline aluminum (Japanese Laid-Open Patent No. Sho59-194393), metal complexes of 10-hydroxybenzo[h]quinoline (Japanese Laid-Open Patent No. Hei6-322362), cyclopentadiene derivatives (Japanese Laid-Open Patent No. Hei2-289675), bisstyrylbenzene 20 derivatives (Japanese Laid-Open Patent Nos. Hei1-245087 and Hei2-222484), perylene derivatives (Japanese Laid-Open Patent Nos. Hei2-189890 and Hei3-791), p-phenylene derivatives (Japanese Laid-Open Patent Nos. Hei3-33183 and Hei1-345686), oxazole derivatives, or the like.

25 Additionally, preferred organic single molecules for use in an electron transport layer include organometal complexes having relatively high stability to electrons and high electron moving rate. Particularly, it is reported that Alq3 is the most 30 preferred, because it has excellent stability and high electron affinity. In addition to the above-mentioned materials, other electron transport materials known to

one skilled in the art include Flavon or silol series available from Chisso Corporation.

There is no especially preferred candidate other than the above materials for use in the electron 5 transport layer. Generally, electron transport materials are used in the form of a mixture with metals for use in cathodes. Otherwise, inorganic materials such as lithium fluoride (LiF) may be used.

The cathode 7 serves to inject electrons to the 10 organic light emitting layer 5. As materials for the cathode, the materials used in the anode 2 may be used. However, it is preferable to use metals having low work function in order to inject electrons more efficiently. Particular examples of the metals include lithium, 15 cesium, sodium, tin, magnesium, indium, calcium, aluminum, etc., and alloys thereof.

However, the organic electroluminescence display device using organic single molecules suitable for each of the layers forming the device generally has short 20 life span and has problems that it provides poor shelf durability and reliability. It is thought that such problems result from physical, chemical, photochemical and electrochemical changes in organic materials, oxidation of cathode, interlayer separation, and 25 melting, crystallization and pyrolysis of organic compounds.

Brief Description of the Drawings

FIG. 1 is a sectional view showing the structure 30 of a conventional organic electroluminescence device.

<Brief description of indication numbers>

- 1: substrate
- 2: anode
- 3: hole injection layer
- 4: hole transport layer
- 5: organic light emitting layer
- 6: electron transport layer
- 7: cathode

Disclosure of the Invention

10 As described above, conventional hole injection materials including organometal complexes such as CuPC, arylamine compounds and carbazole group-containing materials have problems in that they have a difficulty in realizing full color and show poor stability.

15 The present inventors have synthesized novel organic compounds containing a carbazole group, represented by the following formula 1. And They have found that the above novel compounds can provide significantly improved efficiency, lifespan and thermal 20 stability of an organic light emitting device, when used as hole injection and transport materials. The present invention is based on such findings.

As described above, it is possible to realize 25 desired color in an organic electroluminescence device by modifying the structure of a suitable organic single molecule. In this regard, various high-efficiency organic electroluminescence devices are provided by using host-guest systems. However, such devices show insufficient luminance characteristics, lifespan and 30 durability for practical use. Therefore, the present invention has been made in view of the above-mentioned problems. It is an object of the present invention to

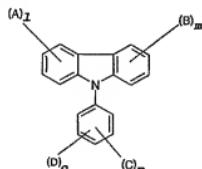
provide a novel material for hole injection and hole transport layer, which can improve luminous efficiency, stability and lifespan of an organic electroluminescence device, and to provide an organic electroluminescence device using the same material.

It is another object of the present invention to provide a material having high glass transition temperature, excellent thermal stability and sublimation property needed for vacuum vapor deposition processes.

According to an aspect of the present invention, there are provided an organic compound represented by the following formula 1 and an organic electroluminescence device comprising the same compound in an organic compound layer:

15

[formula 1]



wherein A is $-\text{[R1-N-]}_z$ or $-\text{[R1-N-Ar-]}_z$;

B is $-\text{[R3-N-]}_4$ or $-\text{[R3-N-Ar-]}_4$;

20 C is $-\text{[R5-N-]}_6$ or $-\text{[R5-N-Ar-]}_6$;

D is H, $-\text{[R7-N-]}_8$ or $-\text{[R9-N-Ar-]}_{10}$.

In the above formula, R1 to R10 are the same or different, and preferably each comprises, only once or

repeatedly at least two times, at least one selected from the group consisting of a hydrogen atom; aliphatic hydrocarbon having 1-20 carbon atoms; aromatic hydrocarbon non-substituted or substituted with a nitro, 5 nitrile, halogen, alkyl, alkoxy or amino group; silicon group having an aromatic substituent; heterocyclic aromatic hydrocarbon non-substituted or substituted with a nitro, nitrile, halogen, alkyl, alkoxy or amino group; thiophene group substituted with a C1-C20 hydrocarbon or 10 C6-C24 aromatic hydrocarbon; and a boron group substituted with an aromatic hydrocarbon, and

Ar is an aromatic hydrocarbon non-substituted or substituted with a nitro, nitrile, halogen, alkyl, alkoxy or amino group.

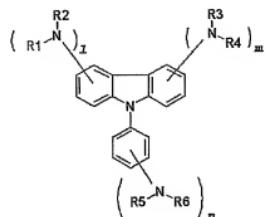
15 In the above formula, each of l, m and n is an integer of 1 or more and o is an integer of 0 or more, preferably, l, m and n represent 1 at the same time, and o is 0, with the proviso that the compound represented by formula 1 wherein R1, R2, R3, R4, R5 and R6 represent 20 hydrogen atoms simultaneously and D is also a hydrogen atom is excluded.

The above aromatic hydrocarbon includes monocyclic aromatic rings such as phenyl, biphenyl and terphenyl and multicyclic aromatic rings such as naphthyl, 25 anthracenyl, phenanthracene, pyrenyl and perylenyl or the like. Additionally, the above heteroaromatic hydrocarbon includes thiophene, furan, pyrrole, imidazole, thiazole, oxazole, oxadiazole, thiadiazole, triazole, pyridyl, pyridazyl, pyrazine, quinoline, 30 isoquinoline, etc.

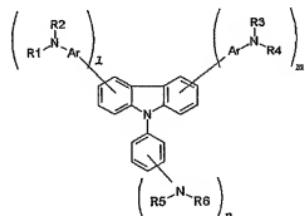
Preferably, the compound represented by the above formula 1 may be a compound represented by any one

formula selected from the following formulae 2a-2e:

【formula 2a】

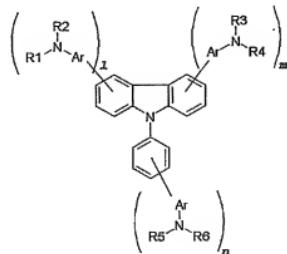


【formula 2b】

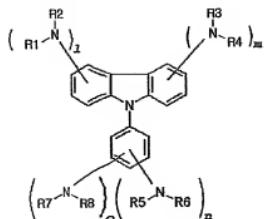


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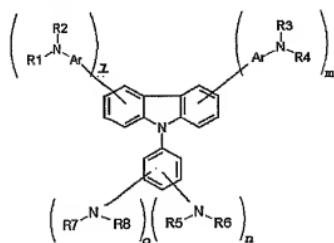
【formula 2c】



【formula 2d】



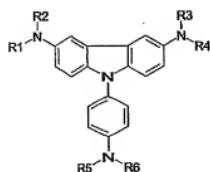
【formula 2e】



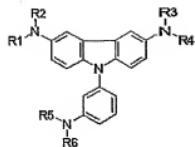
5

More preferably, the compound represented by the above formula 1 may be a compound represented by any one formula selected from the following formulae 3a-3n:

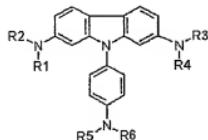
10 【formula 3a】



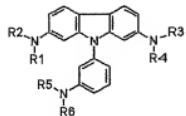
【formula 3b】



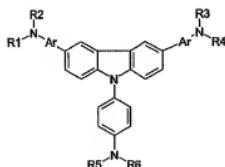
【formula 3c】



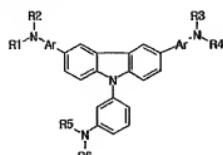
5 【formula 3d】



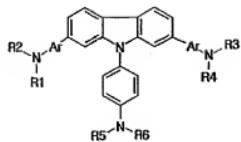
【formula 3e】



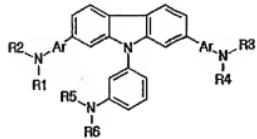
【formula 3f】



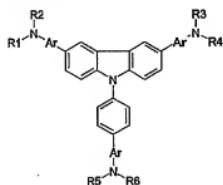
【formula 3g】



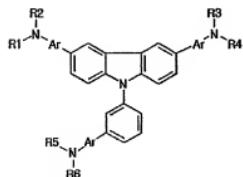
【formula 3h】



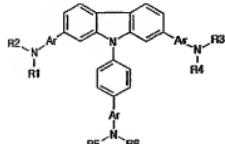
5 【formula 3i】



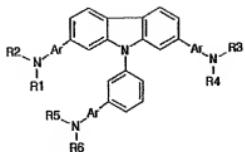
【formula 3j】



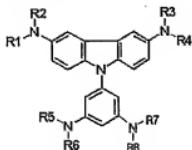
【formula 3k】



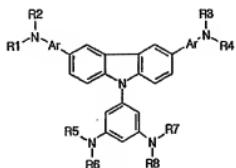
【formula 31】



【formula 3m】



5 【formula 3n】



In the above formulae 2a-2e and 3a-3n, each of R1-R8 is the same as defined with regard to the above 10 formula 1.

Hereinafter, the present invention will be described in more detail.

The organic compounds represented by the formula of 1, 2 or 3 are capable of serving as hole injection and 15 hole transport materials, and thus can be used in at least one layer selected from a hole injection layer, hole transport layer and a light emitting layer in an organic light emitting device.

Particularly, each of the compounds comprises a carbazole group and accepts and transports holes with ease. It is thought that such functions result from the cyclic structure present in the carbazole group and the 5 presence of an aryl group bonded to the carbazole group. Therefore, an organic material layer comprising the above compound may be used as a hole injection layer or hole transport layer. Additionally, the organic material layer may be used as a light emitting layer where holes 10 and electrons are recombined to accomplish light emission. In other words, the compound according to the present invention can perform at least one function selected from the group consisting of hole injection, hole transport and light emission. Similarly, the layer 15 comprising the above compound in an organic light emitting device can serve as at least one selected from the group consisting of a hole injection layer, hole transport layer and a light emitting layer. Additionally, the layer comprising the above compound 20 can be used as a hole injection/hole transport layer, hole injection/hole transport/light emitting layer, etc.

More particularly, it is thought that the compound may accept and transport holes stably and safely by virtue of the aryl group of the carbazole group or the 25 aryl group bonded to the carbazole group as a substituent and the carbazole group itself. In addition, the substituent bonded to the carbazole group is derived from an amine group. Such substituents maintain the movement of holes and the structure of the compound 30 according to the present invention in a stable state, while not disturbing the flow of holes. Therefore, the

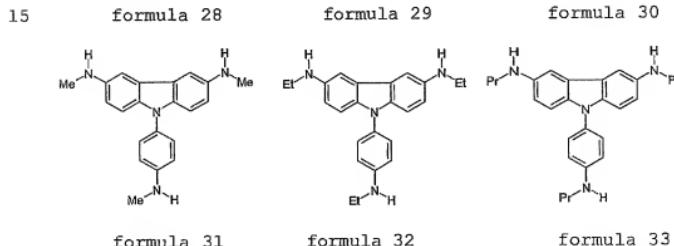
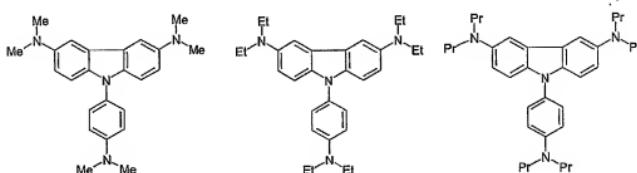
organic light emitting device comprising the compound shows excellent stability and improved lifespan.

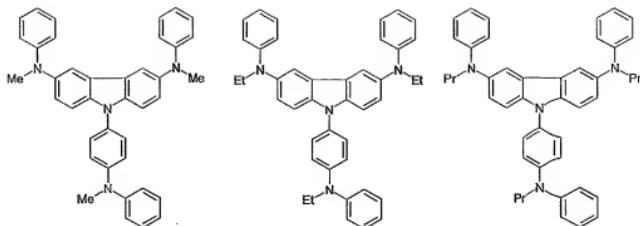
In addition, the substituents of the compound according to the present invention, i.e., R1-R10 may 5 represent any other substituents than the groups as defined above, as long as the compound having substituents corresponding to R1-R10 can perform a desired function as an organic material layer in an organic light emitting device. For example, when R1-R10 10 represent alkyl groups or alkyl-substituted substituents, there is no limitation in the length of each alkyl group. Because the length of an alkyl group included in the compound does not affect the conjugation length of the compound, it has no direct effect on the 15 wavelength of the compound or on the characteristics of a device. However, the length of an alkyl group may affect the selection of a method of applying the compound to an organic light emitting device, for example, a vacuum deposition method or a solution 20 coating method. Therefore, there is no particular limitation in length of alkyl groups that may be included in the compound represented by the above formulae.

With regard to R1-R10 in the above formulae, 25 particular examples of the aromatic compound include monocyclic aromatic rings such as phenyl, biphenyl, terphenyl, etc., and multicyclic aromatic rings such as naphthyl, anthracenyl, pyrenyl, perylenyl, etc. Particular examples of the heteroaromatic compound 30 include thiophene, furan, pyrrole, imidazole, thiazole, oxazole, oxadiazole, thiadiazole, triazole, pyridyl, pyridazyl, pyrazine, quinoline, isoquinoline, etc.

The aliphatic hydrocarbon having 1-20 carbon atoms includes both linear aliphatic hydrocarbons and branched aliphatic hydrocarbons. Particular examples of such hydrocarbons include alkyl groups such as methyl, ethyl, 5 n-propyl, iso-propyl, n-butyl, sec-butyl, iso-butyl, tert-butyl, pentyl, hexyl, etc.; alkenyl groups having a double bond, such as styryl; and alkynyl groups having a triple bond, such as acetylene.

Non-limiting examples of the compound according to 10 the present invention include the compounds represented by the following formulae 28-260.

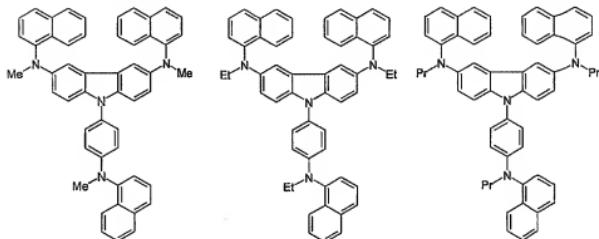




formula 34

formula 35

formula 36

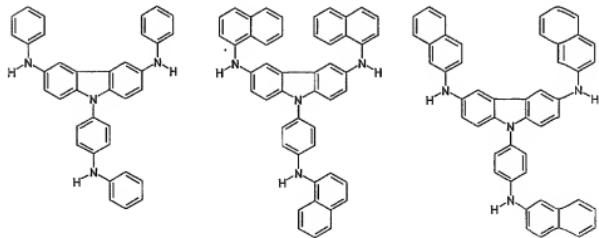


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formula 37

formula 38

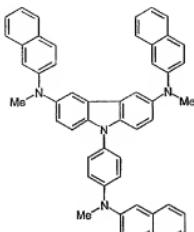
formula 39



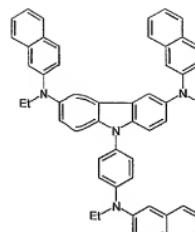
formula 40

formula 41

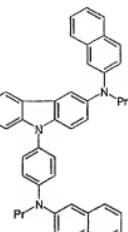
formula 42



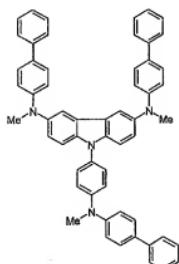
formula 43



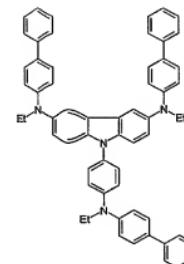
formula 44



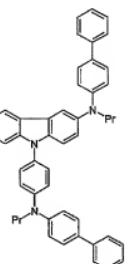
formula 45



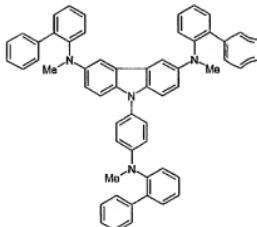
formula 46



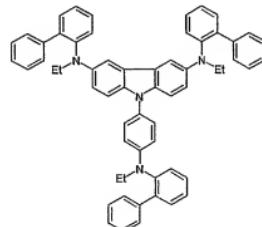
formula 47



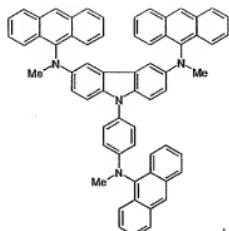
formula 48



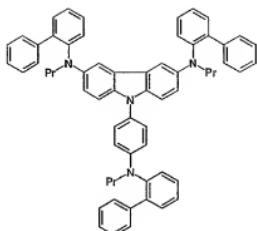
formula 49



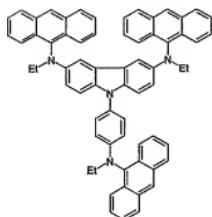
formula 50



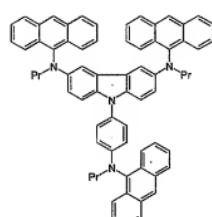
formula 51



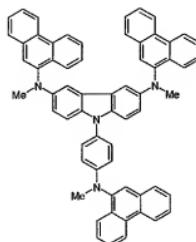
formula 52



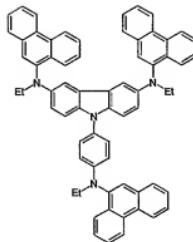
formula 53



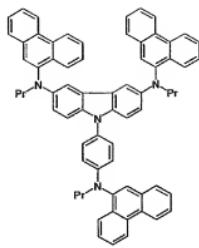
formula 54



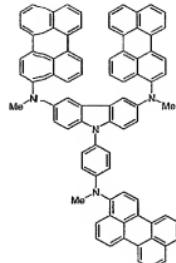
formula 55



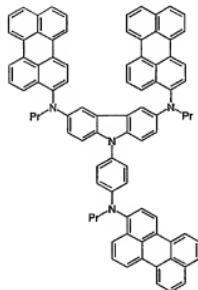
formula 56



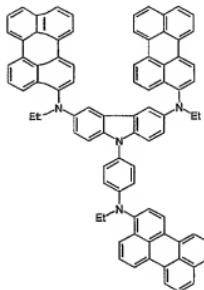
formula 57



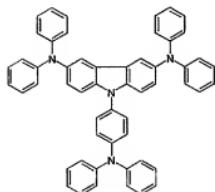
formula 58



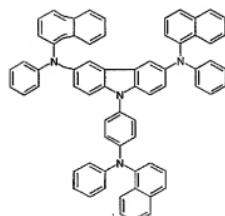
formula 59



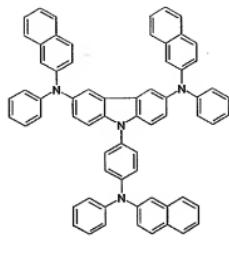
formula 60



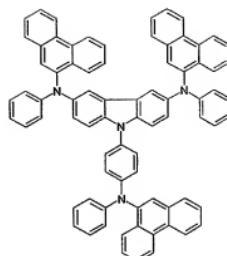
formula 61



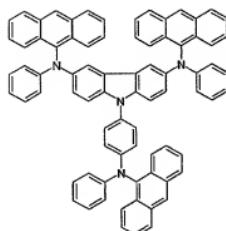
formula 62



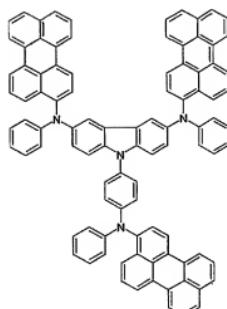
formula 63



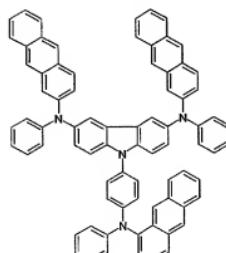
formula 64



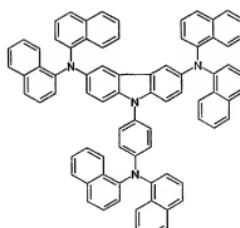
formula 65



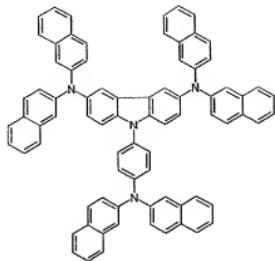
formula 66



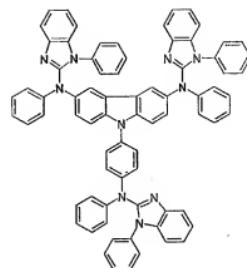
formula 67



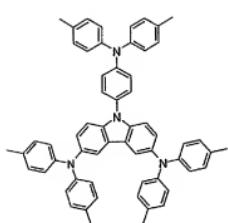
formula 68



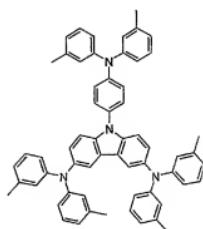
formula 69



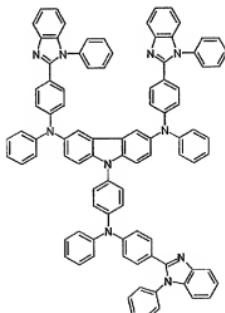
formula 70



formula 71

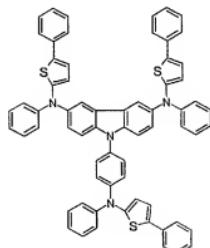


formula 72

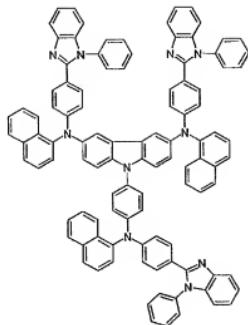


formula 73

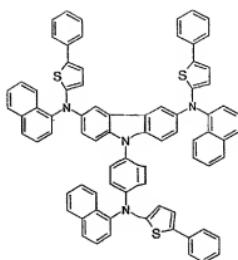
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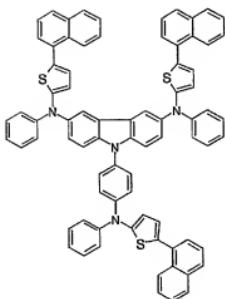
formula 74



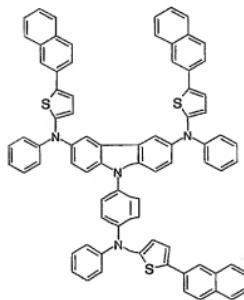
formula 75



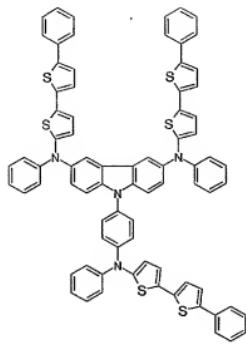
formula 76



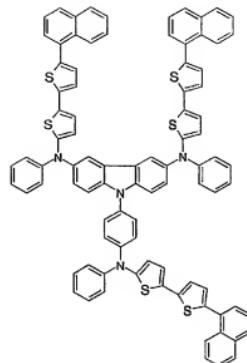
formula 77



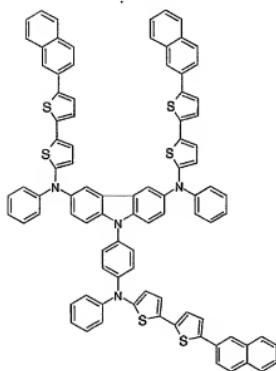
formula 78



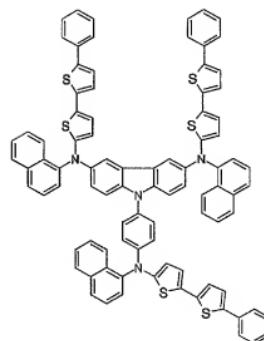
formula 79



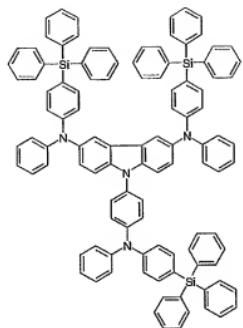
formula 80



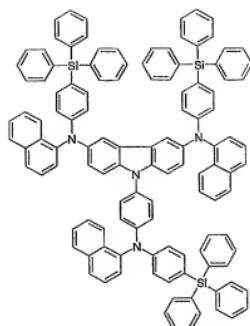
formula 81



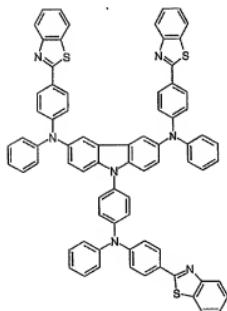
formula 82



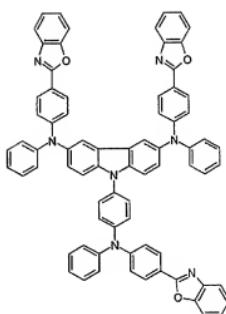
formula 83



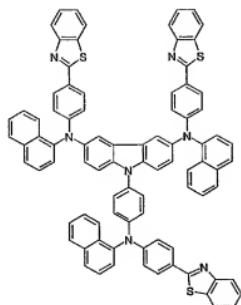
formula 84



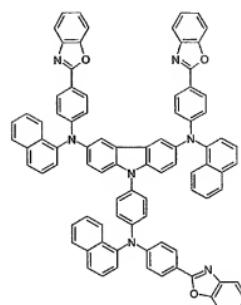
formula 85



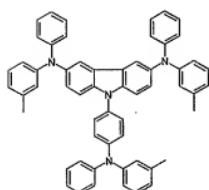
formula 86



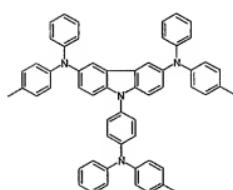
formula 87



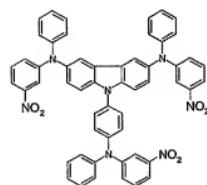
formula 88



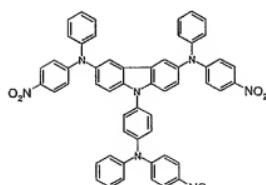
formula 89



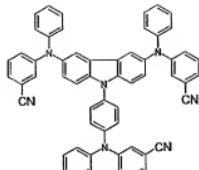
formula 90



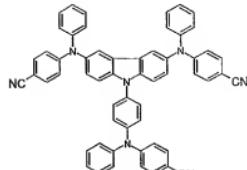
formula 91



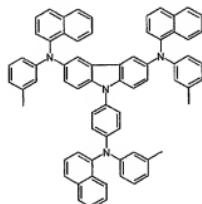
formula 92



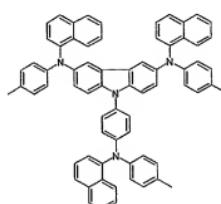
formula 93



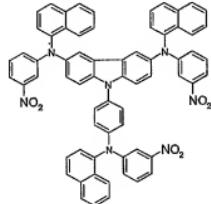
formula 94



formula 95

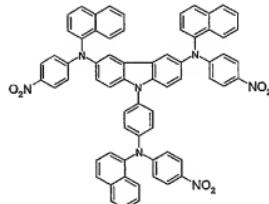


formula 96

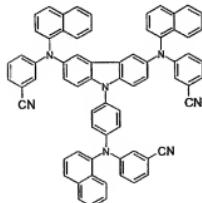


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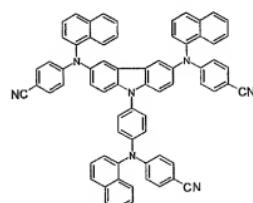
formula 97



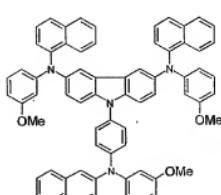
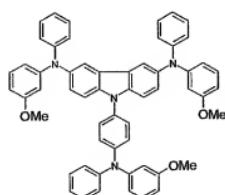
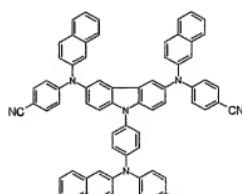
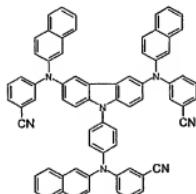
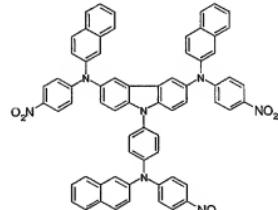
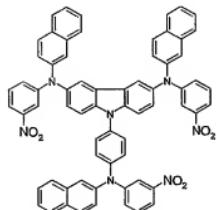
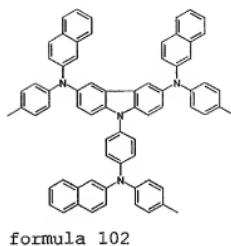
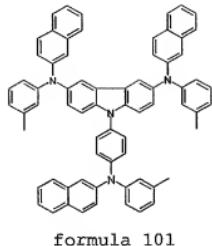
formula 98



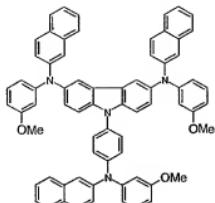
formula 99



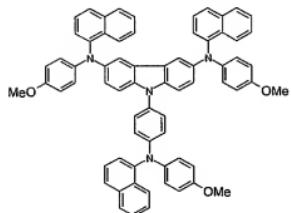
formula 100



formula 107

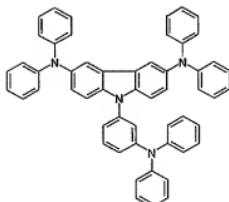


formula 109



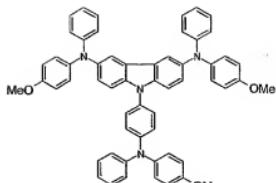
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formula 111

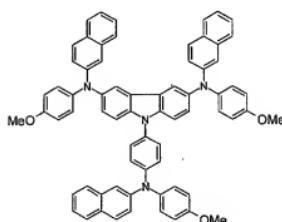


formula 113

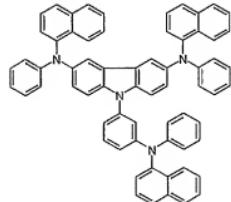
formula 108



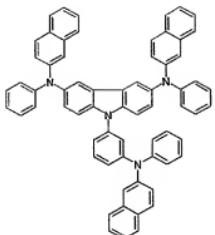
formula 110



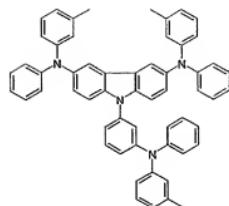
formula 112



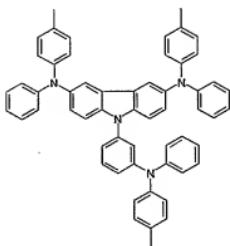
formula 114



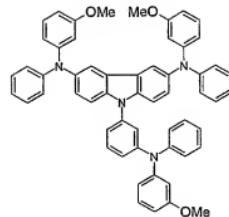
formula 115



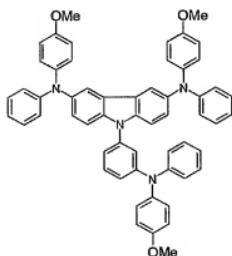
formula 116



formula 117

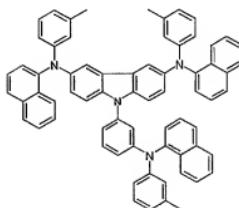


formula 118

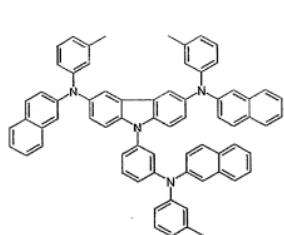


formula 119

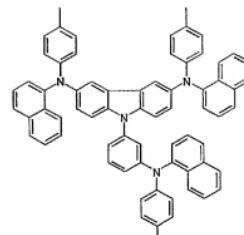
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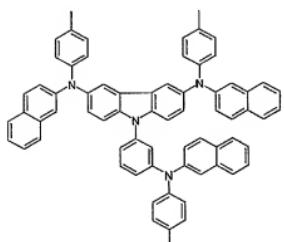
formula 120



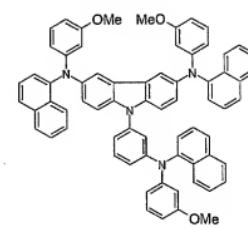
formula 121



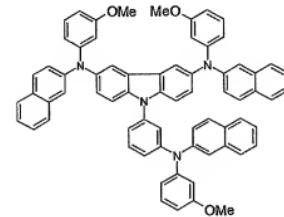
formula 122



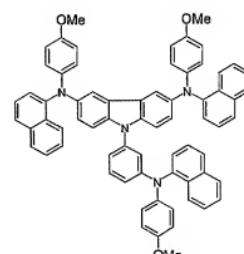
formula 123



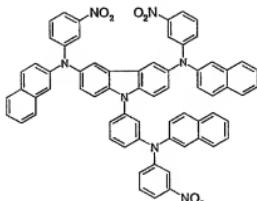
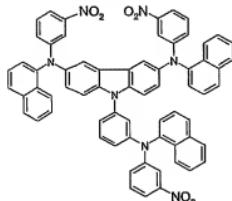
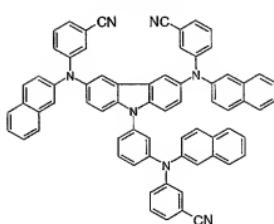
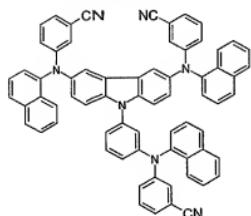
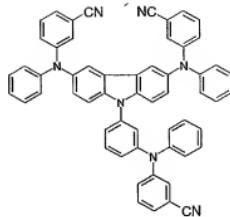
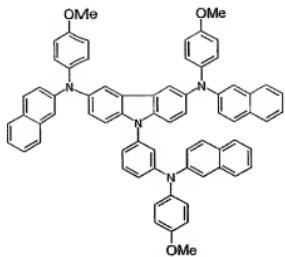
formula 124



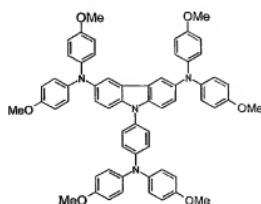
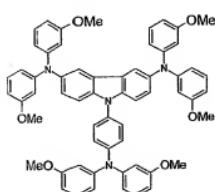
formula 125



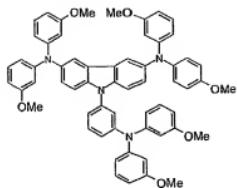
formula 126



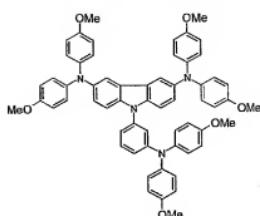
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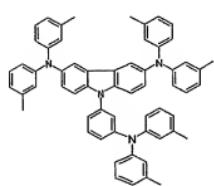
formula 133



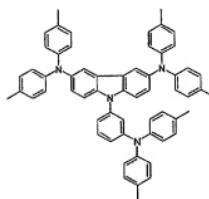
formula 134



formula 135

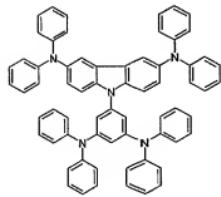


formula 136

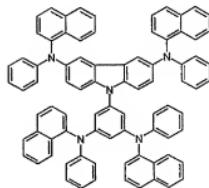


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formula 137

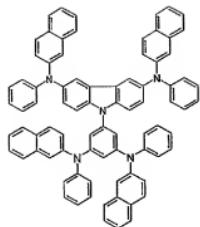


formula 138

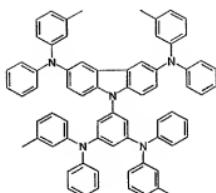


formula 139

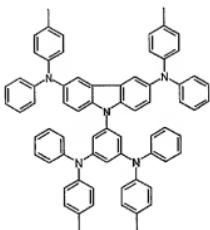
formula 140



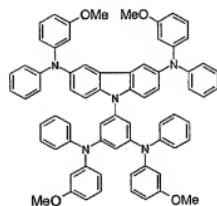
formula 141



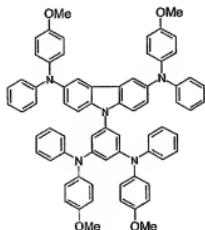
formula 142



formula 143

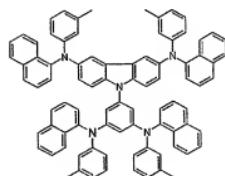


formula 144

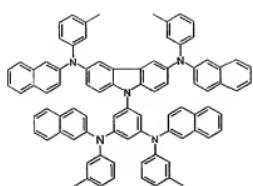


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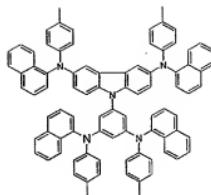
formula 145



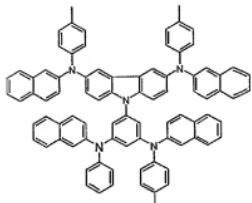
formula 146



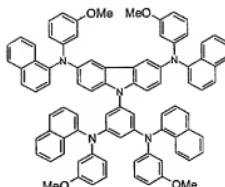
formula 147



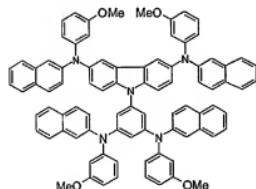
formula 148



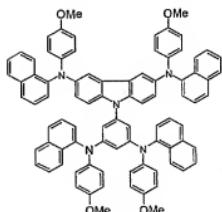
formula 149



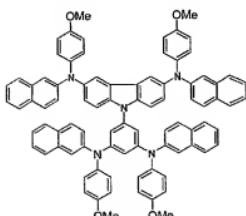
formula 150



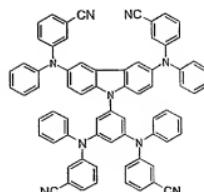
formula 151



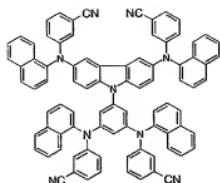
formula 152



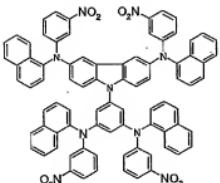
formula 153



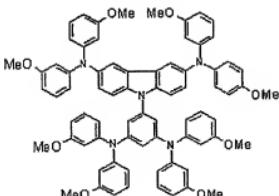
formula 154



formula 155

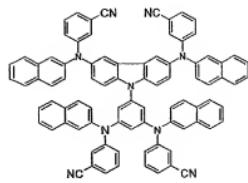


formula 157

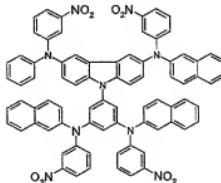


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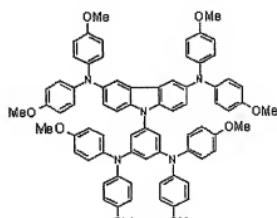
formula 159



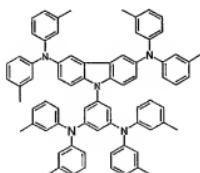
formula 156



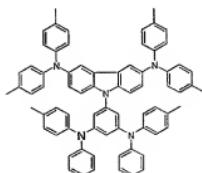
formula 158



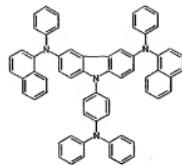
formula 160



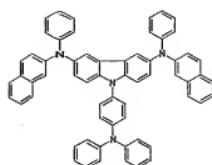
formula 161



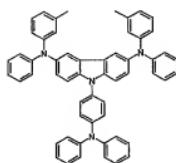
formula 162



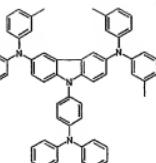
formula 163



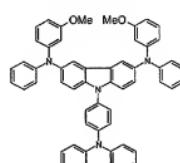
formula 164



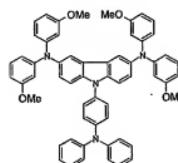
formula 165



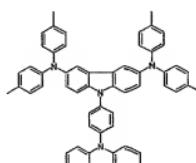
formula 166



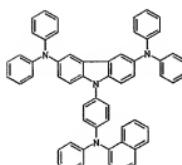
formula 167



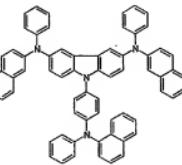
formula 168



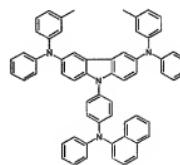
formula 169



formula 170

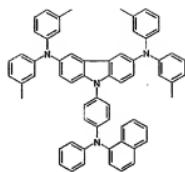


formula 171

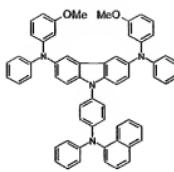


formula 172

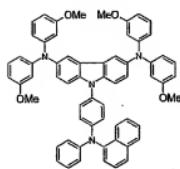
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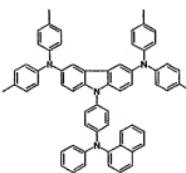
formula 173



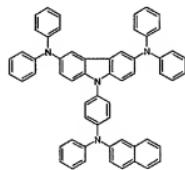
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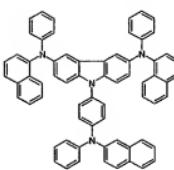
formula 175



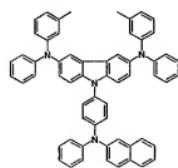
formula 176



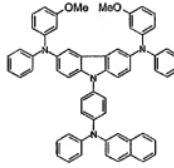
formula 177



formula 178

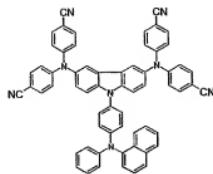


formula 179

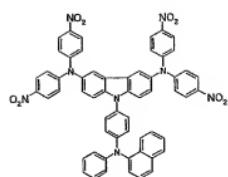


formula 180

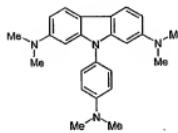
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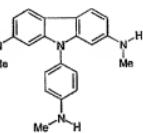
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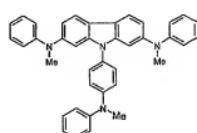
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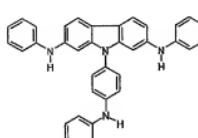
formula 183



formula 184

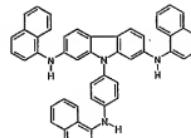


formula 185

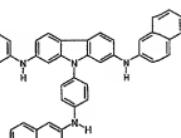


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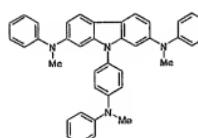
formula 186



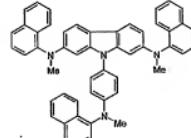
formula 187



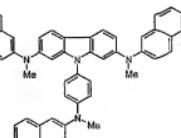
formula 188



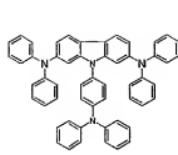
formula 189



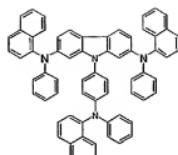
formula 190



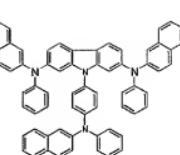
formula 191



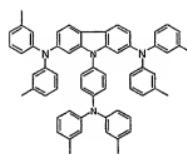
formula 192



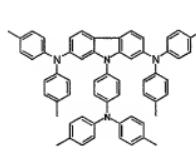
formula 193



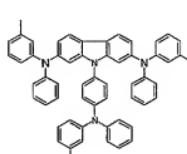
formula 194



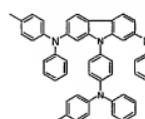
formula 195



formula 196

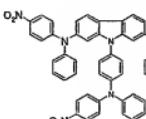


formula 197

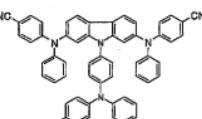


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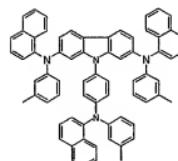
formula 198



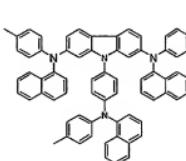
formula 199



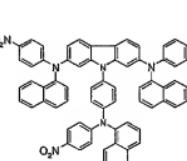
formula 200



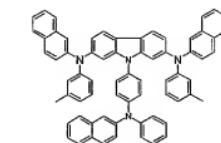
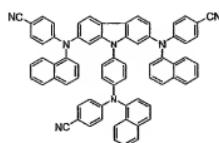
formula 201



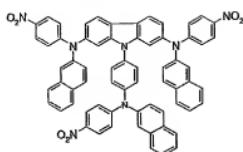
formula 202



formula 203

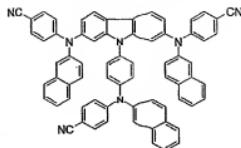


formula 204

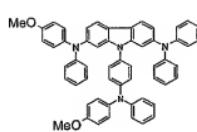


formula 206

formula 205

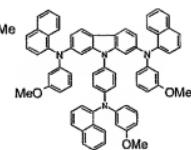


formula 207

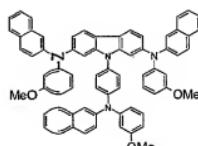


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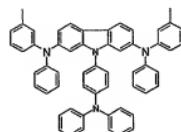
formula 208



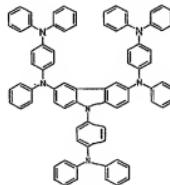
formula 209



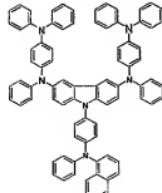
formula 210



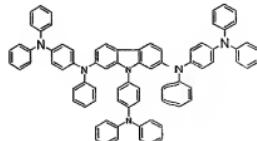
formula 211



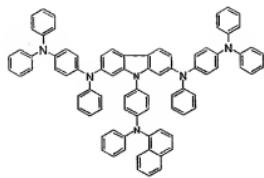
formula 212



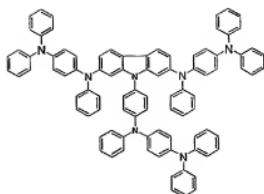
formula 213



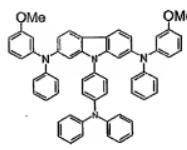
formula 214



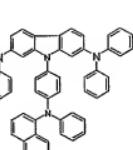
formula 215



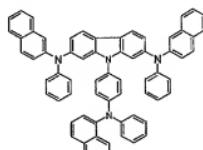
formula 216



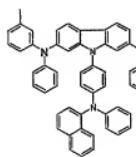
formula 217



formula 218

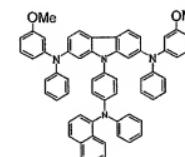


formula 219

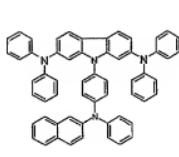


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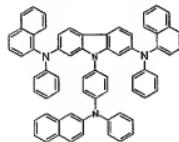
formula 220



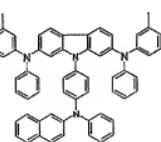
formula 221



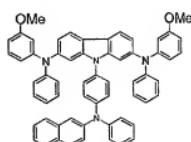
formula 222



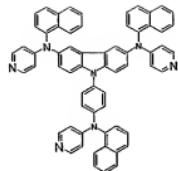
formula 223



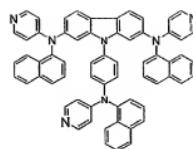
formula 224



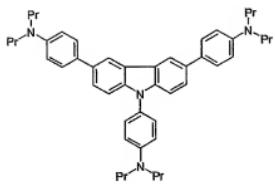
formula 225



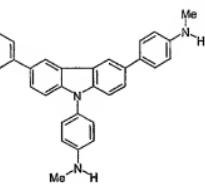
formula 226



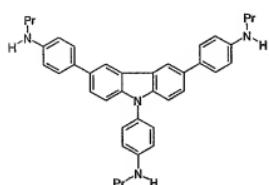
formula 227



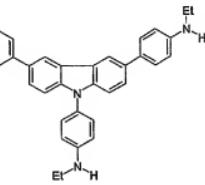
formula 228



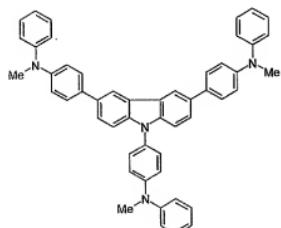
formula 229



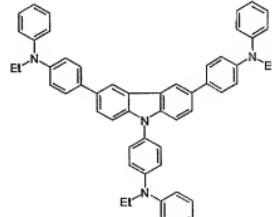
formula 230



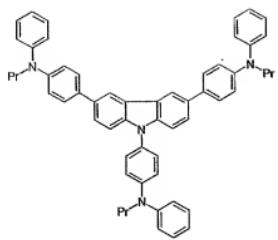
formula 231



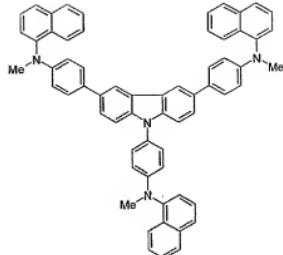
formula 232



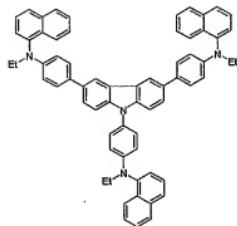
formula 233



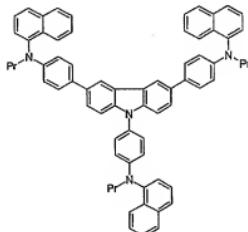
formula 234



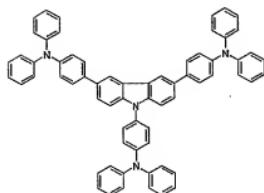
formula 235



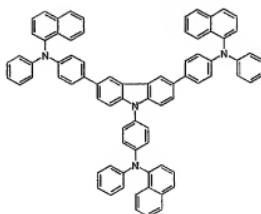
formula 236



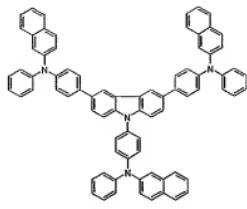
formula 237



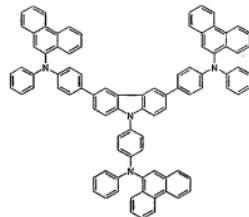
formula 238



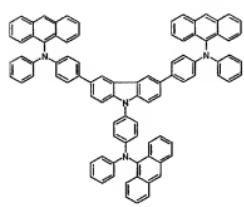
formula 239



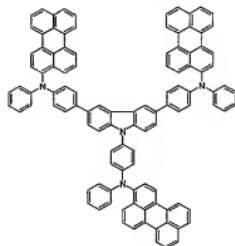
formula 240



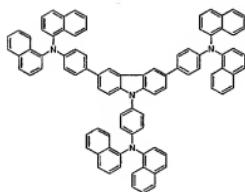
formula 241



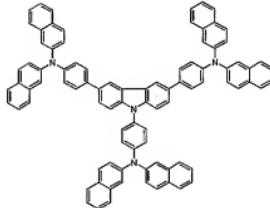
formula 242



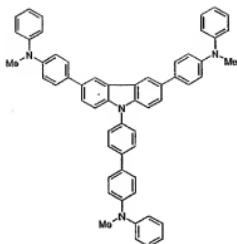
formula 243



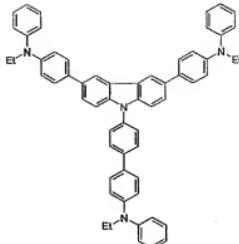
formula 244



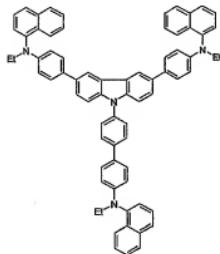
formula 245



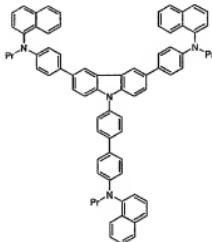
formula 246



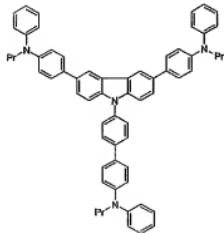
formula 247



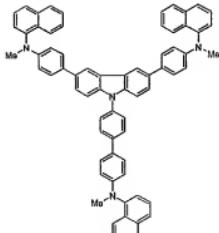
formula 248



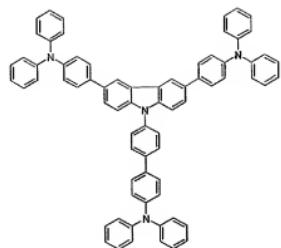
formula 249



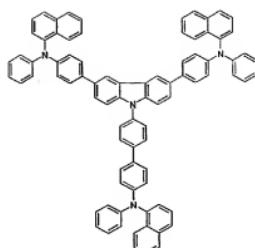
formula 250



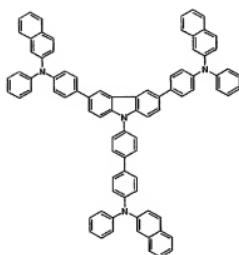
formula 251



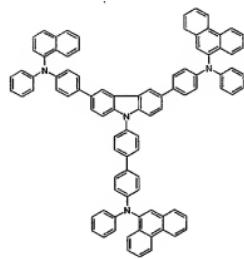
formula 252



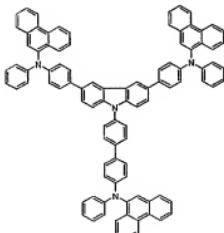
formula 253



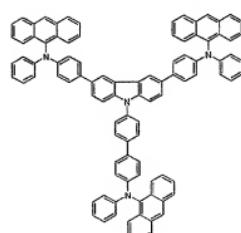
formula 254



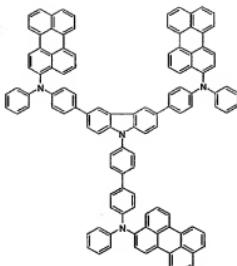
formula 255



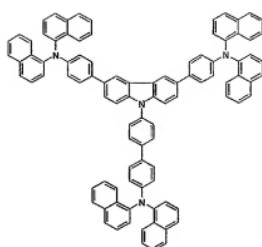
formula 256



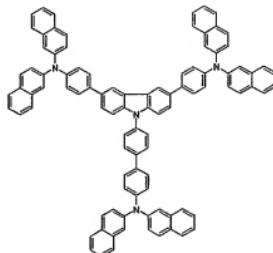
formula 257



formula 258



formula 259



formula 260

5 The organic compounds represented by the above
 formulae may be synthesized from their starting
 materials through three to eight processing steps. In
 one embodiment of the synthetic process, the above
 compounds can be prepared from carbazole. First,
 10 carbazole is treated with a halogen atom or halogenated
 benzene to form a starting material substituted with
 halogen or halogenated benzene. Next, a compound
 corresponding to each of A, B, C, D or R1-R10 of the
 above formula 1 is introduced to the starting material
 15 to substitute for the halogen atom of the starting
 material, thereby forming a desired compound. In the

process, a catalyst may be used. There is no particular limitation in the selection of a halogen atom. Generally, bromine, chlorine, etc. may be used.

It will be appreciated that a suitable synthetic 5 process can be designed by one skilled in the art with reference to the structural formula of the compound according to the present invention.

Synthetic processes for some compounds will be described in the following Examples.

10 FIG. 1 shows a preferred embodiment of the organic electroluminescence device. The organic compound according to the present invention can be used in at least one organic material layer disposed between an anode and cathode, i.e., at least one layer selected 15 from the group consisting of a hole injection layer, hole transport layer and a light emitting layer. More particularly, the compound can be used in a hole injection layer, hole transport layer, hole injection/hole transport layer, or a hole injection/hole 20 transport/light emitting layer.

Meanwhile, it is known that a host material having a large energy gap, for example CBP, is doped with an organic phosphorescent material such as phenylpyridine iridium to provide a high-efficiency device 25 successfully. This indicates that limited efficiency by the singlet-singlet transition may be overcome by triplet-triplet transition. Therefore, when the novel hole injection material according to the present invention is applied as a host material for 30 phosphorescence-based luminescence, it will be possible to obtain an organic electroluminescence device having significantly improved luminous efficiency and lifespan

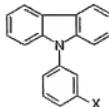
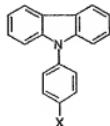
(C. Adachi, M. A. Baldo, and S. R. Forrest, *Applied Physics Letter*, 77, 904, 2000., C. Adachi, M. A. Baldo, S. R. Forrest, S. Lamansky, M. E. Thompson, and R. C. Kwong, *Applied Physics Letter*, 78, 1622, 2001).

5 According to the present invention, the organic electroluminescence devices comprising the compounds represented by the above formulae 1-3 and 28-260 in organic material layers can provide significantly improved efficiency and lifespan and show excellent 10 stability.

Best Mode for Carrying Out the Invention

Hereinafter, synthetic processes of the organic compound represented by the above formula 1 and 15 manufacture of organic electroluminescence devices using the same will be described in more detail through Examples and Comparative Examples. It is to be understood that the following examples are illustrative only and the present invention is not limited thereto.

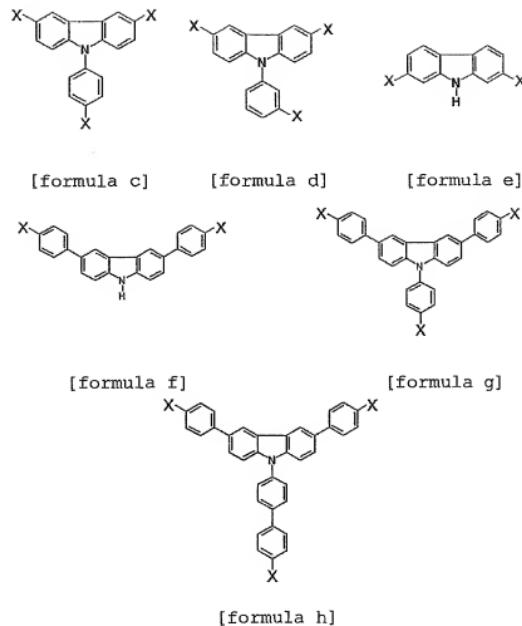
20 In order to prepare the compound represented by the above formula 1, the compounds represented by the following formulae a-h may be used as starting materials.



25

[formula a]

[formula b]



5

In the above formulae a-h, X represents a halogen atom. There is no particular limitation in the selection 10 of a halogen atom. In the following examples, the compounds represented by formulae a-h wherein X is Br are selected as starting materials. The starting materials are prepared according to the following Preparation Examples 1 to 8.

15 **<Preparation Example 1> Preparation of the starting material represented by formula a**

Carbazole (5.00 g, 29.9 mmol), 1-bromo-4-iodobenzene (9.30 g, 32.9 mmol), K_2CO_3 (16.5 g, 120

mmol), Cu (3.80 g, 59.8 mmol) and 18-crown-6 (0.40 g, 1.49 mmol) were refluxed in 50 ml of o-dichlorobenzene for 15 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and the 5 precipitate was filtered off. The filtrate was washed with water three times, dried over MgSO₄ and concentrated under reduced pressure. The reaction mixture was purified by column chromatography to obtain the compound represented by formula a as starting material (5.85 g, 10 61%). ¹H NMR (300 MHz, CDCl₃) 8.13-8.11(d, 2H), 7.71-7.69(d, 2H), 7.44-7.21(m, 8H); MS [M+H] 322.

<Preparation Example 2> Preparation of the starting material represented by formula b

Carbazole (5.00 g, 29.9 mmol), 1-bromo-3-15 iodobenzene (9.30 g, 32.9 mmol), K₂CO₃ (16.5 g, 120 mmol), Cu (3.80 g, 59.8 mmol) and 18-crown-6 (0.40 g, 1.49 mmol) were refluxed in 50 ml of o-dichlorobenzene for 15 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and the 20 precipitate was filtered off. The filtrate was washed with water three times, dried over MgSO₄ and concentrated under reduced pressure. The reaction mixture was purified by column chromatography to obtain the compound represented by formula b as starting material (5.85 g, 25 61%). MS [M+H] 322.

<Preparation Example 3> Preparation of the starting material represented by formula c

The starting material represented by formula a (1.50 g, 4.66 mmol) was dissolved in dimethylformamide (DMF, 20 ml) and N-bromosuccinimide (NBS, 1.82 g, 10.2 mmol) was added thereto. The reaction mixture was reacted at 50-60°C for 2 hours and water (15 ml) was

added thereto. The resultant precipitate was filtered, washed with water and then recrystallized in dichloromethane/n-hexane to obtain the compound represented by formula c as starting material (1.93 g, 86%). ^1H NMR(300 MHz, CDCl_3) 8.17(s, 2H), 7.75-7.74(d, 2H), 7.51-7.48(d, 2H), 7.38-7.35(d, 2H), 7.22-7.19(d, 2H); MS [M+H] 478.

10 **<Preparation Example 4> Preparation of the starting material represented by formula d**

15 The starting material represented by formula b (1.50 g, 4.66 mmol) was dissolved in dimethylformamide (DMF, 20 ml) and N-bromosuccinimide (NBS, 1.82 g, 10.2 mmol) was added thereto. The reaction mixture was reacted at 50-60°C for 2 hours and water (15 ml) was added thereto. The resultant precipitate was filtered, washed with water and then recrystallized in dichloromethane/n-hexane to obtain the compound represented by formula d as starting material (1.93 g, 86%). MS[M+H] 478.

20 **<Preparation Example 5> Preparation of the starting material represented by formula e**

25 2,5-dibromonitrobenzene (12.0 g, 42.7 mmol) was dissolved in dimethylformamide (DMF, 80 ml), Cu (6.0 g, 93.94 mmol) was added thereto, and then the reaction mixture was reacted at 120°C for 3 hours. The reaction mixture was cooled to room temperature, the insoluble material was filtered off and the filtrate was concentrated. The resultant product was recrystallized in ethanol to obtain 4,4'-dibromo-2,2'-dinitrobiphenyl (10.2 g, 60%). MS[M+] 354.

30 4,4'-dibromo-2,2'-dinitrobiphenyl (6.1 g, 15.17 mmol) was stirred in HCl 30 ml/EtOH 75 ml, Sn powder

(7.2 g, 60.68 mmol) was added thereto, and then the reaction mixture was refluxed for 24 hours. Next, the reaction mixture was cooled to room temperature, neutralized with 10% NaOH solution, and then 5 recrystallized in ethanol to obtain 4,4'-dibromo-2,2'-diaminobiphenyl (3.5 g, 67%). MS[M+H] 341.

4,4'-dibromo-2,2'-diaminobiphenyl (3.5 g, 10.23 mmol) was dissolved in phosphoric acid and heated at 10 190°C for 24 hours. The reaction mixture was cooled to room temperature and then NaHCO₃ (aq) was gradually added thereto to form a solid. Then, the solid was filtered to obtain 2,7-dibromocarbazole (2.2 g, 66%), the compound represented by formula e. MS[M+] 323.

15 **<Preparation Example 6> Preparation of the starting material represented by formula f**

3,6-dibromocarbazole (1.63 g, 5.00 mmol), 4-bromophenylboronic acid (2.95 g, 15.0 mmol), 2M potassium carbonate solution (10 ml) and tetrakis(triphenylphosphine)palladium (29.0 mg, 0.25 mmol) were added to 100 ml of THF. The reaction mixture was stirred under reflux for about 24 hours and then cooled to room temperature. Next, the reaction mixture was introduced into toluene and brine and the toluene layer was separated. The separated layer was dried over 20 MgSO₄, filtered and concentrated. Then, the reaction mixture was purified by column chromatography to obtain the compound represented by formula f as starting material (1.15 g, 48%). ¹H NMR(300 MHz, CDCl₃) 10.1(s, 1H), 7.77(s, 2H), 7.49-7.46(m, 6H), 7.37(d, 4H), 7.30(d, 2H); MS [M+H] 476.

30 **<Preparation Example 7> Preparation of the starting material represented by formula g**

The compound represented by formula f (1.43 g, 3.00 mmol), 1-bromo-4-iodobenzene (1.87 g, 6.60 mmol), K_2CO_3 (3.32 g, 24 mmol), Cu (0.76 g, 12.0 mmol) and 18-crown-6 (0.08 g, 0.30 mmol) were refluxed in 10 ml of o- dichlorobenzene for 15 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and the precipitate was filtered off. The filtrate was washed with water three times, dried over $MgSO_4$ and concentrated under reduced pressure. The 10 reaction mixture was purified by column chromatography to obtain the compound represented by formula g as starting material (1.02 g, 54%). 1H NMR (300 MHz, $CDCl_3$) 7.77(s, 2H), 7.49-7.40(m, 8H), 7.37(d, 4H), 7.30(d, 2H), 7.20(d, 2H); MS [M+H] 630.

15 **<Preparation Example 8> Preparation of the starting material represented by formula h**

The compound represented by formula c (2.40 g, 5.00 mmol), 4-bromophenylboronic acid (3.94 g, 20.0 mmol), 2M potassium carbonate solution (20 ml) and 20 tetrakis(triphenylphosphine)palladium (58.0 mg, 0.50 mmol) were added to 100 ml of THF. The reaction mixture was stirred under reflux for about 24 hours and then cooled to room temperature. Next, the reaction mixture was introduced into toluene and brine and the toluene 25 layer was separated. The separated layer was dried over $MgSO_4$, filtered and concentrated. Then, the reaction mixture was purified by column chromatography to obtain the compound represented by formula h as starting material (2.09 g, 59%). 1H NMR (300 MHz, $CDCl_3$) 7.77(s, 2H), 7.50-7.46(m, 10H), 7.37(m, 6H), 7.30(m, 4H); MS [M+H] 706.

30 **<Example 1> Preparation of the compound**

represented by formula 61

The compound represented by formula c (1.00 g, 2.08 mmol), diphenylamine (1.16 g, 6.86 mmol), $\text{Pd}_2(\text{dba})_3$ (0.125 g, 0.13 mmol), $\text{P}(\text{t-Bu})_3$ (0.04 g, 0.2 mmol) and 5 sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic 10 layer was separated, dried over MgSO_4 and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 61 (1.16 g, 75%). ^1H NMR (300 MHz, CDCl_3) 6.78(d, 2H), 6.96(m, 14H), 7.12(m, 6H), 7.25(s, 2H), 7.5-7.51(m, 15 14H), 7.65(d, 2H); MS [M+H] 745.

<Example 2> Preparation of the compound represented by formula 62

The compound represented by formula c (1.00 g, 2.08 mmol), N-phenyl-1-naphthylamine (1.50 g, 6.86 mmol), $\text{Pd}_2(\text{dba})_3$ (0.125 g, 0.13 mmol), $\text{P}(\text{t-Bu})_3$ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the 25 reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over MgSO_4 and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by 30 formula 62 (1.46 g, 79%). ^1H NMR (300 MHz, CDCl_3) 6.78(d, 2H), 6.96-7.12(m, 14H), 7.25(s, 2H), 7.5-7.51(m, 8H),

7.65-7.66(m, 8H), 7.80-7.81(m, 6H), 8.11-8.12(m, 6H); MS [M+H] 895.

<Example 3> Preparation of the compound represented by formula 63

5 The compound represented by formula c (1.00 g, 2.08 mmol), N-phenyl-2-naphthylamine (1.50 g, 6.86 mmol), Pd₂(dba)₃ (0.125 g, 0.13 mmol), P(t-Bu)₃ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was
10 refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by
15 column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 63 (1.21 g, 65%). ¹H NMR (300 MHz, CDCl₃) 6.78(d, 2H), 6.96-7.0(m, 8H), 7.12(m, 3H), 7.25-7.29(m, 8H), 7.51-7.73(m, 16H), 7.94-8.05(m, 9H); MS [M+H] 895.

20 **<Example 4> Preparation of the compound represented by formula 64**

25 The compound represented by formula c (1.00 g, 2.08 mmol), N-phenyl-(9-phenanthrenyl)amine (1.85 g, 6.86 mmol), Pd₂(dba)₃ (0.125 g, 0.13 mmol), P(t-Bu)₃ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O.
30 The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl

acetate/n-hexane to obtain the compound represented by formula 64 (0.93 g, 43%). ^1H NMR (300 MHz, CDCl_3) 6.78(d, 2H), 6.96-6.97(m, 8H), 7.12(t, 3H), 7.25(s, 2H), 7.41(m, 3H), 7.5-7.51(m, 8H), 7.65(d, 2H), 8.32-8.38(m, 12H), 8.62(d, 6H), 9.43(m, 6H); MS [M+H] 1045.

5 **<Example 5> Preparation of the compound represented by formula 65**

The compound represented by formula c (1.00 g, 2.08 mmol), N-phenyl-(9-anthrenyl)amine (1.85 g, 6.86 mmol), $\text{Pd}_2(\text{dba})_3$ (0.125 g, 0.13 mmol), $\text{P}(\text{t-Bu})_3$ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over MgSO_4 and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 65 (1.24 g, 57%). ^1H NMR (300 MHz, CDCl_3) 6.78(d, 2H), 6.96-6.98(m, 8H), 7.12(t, 3H), 7.23(s, 2H), 7.5-7.51(m, 8H), 7.65-7.66(m, 7H), 7.81-7.84(m, 10H), 8.14-8.15(m, 12H); MS [M+H] 1045.

25 **<Example 6> Preparation of the compound represented by formula 68**

The compound represented by formula c (1.00 g, 2.08 mmol), di-(1-naphthyl)amine (1.85 g, 6.86 mmol), $\text{Pd}_2(\text{dba})_3$ (0.125 g, 0.13 mmol), $\text{P}(\text{t-Bu})_3$ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and

added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 68 (1.04 g, 48%). ¹H NMR (300 MHz, CDCl₃) 6.78(d, 2H), 7.0-7.05(m, 8H), 7.25(s, 2H), 7.50-7.66(m, 16H), 7.80-7.81(m, 12H), 8.11-8.16(m, 12H); MS [M+H] 1045.

10 <Example 7> Preparation of the compound
represented by formula 69

The compound represented by formula c (1.00 g, 2.08 mmol), di-(2-naphthyl)amine (1.85 g, 6.86 mmol), Pd₂(dba)₃ (0.125 g, 0.13 mmol), P(t-Bu)₃ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were 15 added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then 20 concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 69 (0.89 g, 41%). ¹H NMR (300 MHz, CDCl₃) 6.78(d, 2H), 7.0(d, 2H), 7.26-7.29(m, 14H), 7.5-7.53(m, 16H), 25 7.94-8.05(m, 18H); MS [M+H] 1045.

<Example 8> Preparation of the compound
represented by formula 71

The compound represented by formula c (1.50 g, 3.13 mmol), p,p'-ditolylamine (2.03 g, 10.3 mmol), 30 Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was refluxed for

about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then 5 concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 71 (1.31 g, 50%). ¹H NMR (300 MHz, CDCl₃) 2.55(s, 18H), 6.48-6.70(m, 16H), 6.95-7.01(m, 14H), 7.2-7.35(m, 10 4H); MS [M+H] 829.

<Example 9> Preparation of the compound represented by formula 72

The compound represented by formula c (1.50 g, 3.13 mmol), m,m'-ditolylamine (1.96 ml, 10.3 mmol), 15 Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and 20 added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 72 (1.55 g, 60%). ¹H NMR (300 MHz, CDCl₃) 2.55(s, 18H), 6.48-6.70(m, 16H), 6.95-7.01(m, 14H), 7.2-7.35(m, 25 4H); MS [M+H] 829.

<Example 10> Preparation of the compound represented by formula 89

30 The compound represented by formula c (1.50 g, 3.13 mmol), 3-methyldiphenylamine (1.88 g, 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31

mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and 5 added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by 10 formula 89 (1.62 g, 66%). MS[M+H] 787.

<Example 11> Preparation of the compound represented by formula 95

The compound represented by formula c (1.50 g, 3.13 mmol), N-(3-methylphenyl)-1-naphthylamine (2.40 g, 15 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room 20 temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by 25 formula 95 (1.92 g, 65%). MS[M+H] 937.

<Example 12> Preparation of the compound represented by formula 96

The compound represented by formula c (1.50 g, 3.13 mmol), N-(4-methylphenyl)-1-naphthylamine (2.40 g, 30 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was

refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and 5 then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 96 (1.92 g, 65%). MS[M+H] 937.

**<Example 13> Preparation of the compound
10 represented by formula 101**

The compound represented by formula c (1.50 g, 3.13 mmol), N-(3-methylphenyl)-2-naphthylamine (2.40 g, 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 15 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and 20 then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 101 (1.92 g, 65%). MS[M+H] 937.

**<Example 14> Preparation of the compound
25 represented by formula 102**

The compound represented by formula c (1.50 g, 3.13 mmol), N-(4-methylphenyl)-2-naphthylamine (2.40 g, 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 30 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room

temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 102 (1.92 g, 65%). MS[M+H] 937.

<Example 15> Preparation of the compound represented by formula 113

The compound represented by formula d (1.00 g, 10 2.08 mmol), diphenylamine (1.16 g, 6.86 mmol), Pd₂(dba)₃ (0.125 g, 0.13 mmol), P(t-Bu)₃ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the 15 reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 113 (1.16 g, 75%). MS[M+H] 745.

<Example 16> Preparation of the compound represented by formula 114

The compound represented by formula d (1.00 g, 25 2.08 mmol), N-phenyl-1-naphthylamine (1.50 g, 6.86 mmol), Pd₂(dba)₃ (0.125 g, 0.13 mmol), P(t-Bu)₃ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the 30 reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and

then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 114 (1.46 g, 79%). MS[M+H] 895.

5 **<Example 17> Preparation of the compound represented by formula 115**

The compound represented by formula d (1.00 g, 2.08 mmol), N-phenyl-2-naphthylamine (1.50 g, 6.86 mmol), Pd₂(dba)₃ (0.125 g, 0.13 mmol), P(t-Bu)₃ (0.04 g, 0.2 mmol) and sodium tert-butoxide (1.80 g, 18.7 mmol) were added to xylene (40 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. 10 The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 115 (1.21 g, 65%). MS[M+H] 895.

15 **<Example 18> Preparation of the compound represented by formula 116**

The compound represented by formula d (1.50 g, 3.13 mmol), 3-methyldiphenylamine (1.88 g, 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic 20 layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl

acetate/n-hexane to obtain the compound represented by formula 116 (1.62 g, 66%). MS[M+H] 787.

<Example 19> Preparation of the compound represented by formula 120

5 The compound represented by formula d (1.50 g, 3.13 mmol), N-(3-methylphenyl)-1-naphthylamine (2.40 g, 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was
10 refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by
15 column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 120 (1.92 g, 65%). MS[M+H] 937.

<Example 20> Preparation of the compound represented by formula 121

20 The compound represented by formula d (1.50 g, 3.13 mmol), N-(3-methylphenyl)-2-naphthylamine (2.40 g, 10.3 mmol), Pd₂(dba)₃ (0.19 g, 0.21 mmol), P(t-Bu)₃ (0.06 g, 0.31 mmol) and sodium tert-butoxide (1.05 g, 10.96 mmol) were added to xylene (30 ml) and the mixture was
25 refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by
30 column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 121 (1.92 g, 65%). MS[M+H] 937.

<Example 21> Preparation of the compound
represented by formula 192

1) The compound represented by formula e (5.0 g, 15.38 mmol) and di-tert-butyl-dicarbonate (5.04 g, 23.08 mmol) were dissolved in 50 ml of THF and 4-(dimethylamino)pyridine (0.19 g, 1.54 mmol) was added thereto. Then, the reaction mixture was reacted at room temperature for 24 hours. After the completion of the reaction, the reaction mixture was concentrated and 10 recrystallized in ethanol to obtain a product (6.16 g, 94%).

2) The product obtained from step 1) (6.16 g, 14.49 mmol), diphenylamine (5.89 g, 34.78 mmol), sodium tert-butoxide (4.18 g, 43.47 mmol), $Pd_2(dbu)_3$ (0.17 g, 0.29 mmol) and $P(t-Bu)_3$ (0.06 g, 0.29 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic 20 layer was separated, dried over $MgSO_4$ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain a compound (5.88 g, 67%).

3) The compound obtained from step 2) (5.88 g, 9.77 mmol) was dissolved in trifluoroacetic acid/chloroform = 50 ml/50 ml and the solution was refluxed for 3 hours. The reaction mixture was cooled to room temperature, quenched with aqueous NaOH solution, extracted with methylene chloride (MC) and then washed 30 with water many times. The resultant product was dried over magnesium sulfate and allowed to evaporate. The crude product was purified by column chromatography

(ethyl acetate/hexane = 1/9) to obtain a compound (2.9 g, 59%).

4) The product obtained from step 3) (2.9 g, 5.78 mmol), 4-bromophenyl-diphenylamine (1.36 g, 4.21 mmol), 5 $Pd_2(dbu)_3$ (0.05 g, 0.084 mmol) and $P(t-Bu)_3$ (0.017 g, 0.084 mmol) and sodium tert-butoxide (1.21 g, 12.63 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room 10 temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over $MgSO_4$ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by 15 formula 192 (1.5 g, 49%). $MS[M+H]$ 745.

<Example 22> Preparation of the compound represented by formula 193

1) The compound represented by formula e (5.0 g, 15.38 mmol) and di-tert-butyl-dicarbonate (5.04 g, 23.08 20 mmol) were dissolved in 50 ml of THF and 4-(dimethylamino)pyridine (0.19 g, 1.54 mmol) was added thereto. Then, the reaction mixture was reacted at room temperature for 24 hours. After the completion of the reaction, the reaction mixture was concentrated and 25 recrystallized in ethanol to obtain a product (6.16 g, 94%).

2) The product obtained from step 1) (6.16 g, 14.49 mmol), N-phenyl-1-naphthylamine (7.63 g, 34.78 mmol), sodium tert-butoxide (4.18 g, 43.47 mmol), 30 $Pd_2(dbu)_3$ (0.17 g, 0.29 mmol) and $P(t-Bu)_3$ (0.06 g, 0.29 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the

reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄, and then concentrated. The resultant product was purified by 5 column chromatography and recrystallized in ethyl acetate/n-hexane to obtain a compound (6.0 g, 59%).

3) The compound obtained from step 2) (6.0 g, 8.54 mmol) was dissolved in trifluoroacetic acid/chloroform = 50 ml/50 ml and the solution was refluxed for 3 hours. 10 The reaction mixture was cooled to room temperature, quenched with aqueous NaOH solution, extracted with methylene chloride and then washed with water many times. The resultant product was dried over magnesium sulfate and allowed to evaporate. The crude product was 15 purified by column chromatography (ethyl acetate/hexane = 1/9) to obtain a compound (3.8 g, 74%).

4) The product obtained from step 3) (3.8 g, 6.31 mmol), 4-bromophenyl-N-phenyl-1-naphthylamine (1.57 g, 4.21 mmol), Pd₂(dba)₃ (0.05 g, 0.084 mmol) and P(t-Bu)₃ 20 (0.017 g, 0.084 mmol) and sodium tert-butoxide (1.21 g, 12.63 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. 25 The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 193 (1.2 g, 32%). MS[M+H] 895.

30 <Example 23> Preparation of the compound represented by formula 194

1) The compound represented by formula e (5.0 g,

15.38 mmol) and di-*tert*-butyl-dicarbonate (5.04 g, 23.08 mmol) were dissolved in 50 ml of THF and 4-(dimethylamino)pyridine (0.19 g, 1.54 mmol) was added thereto. Then, the reaction mixture was reacted at room 5 temperature for 24 hours. After the completion of the reaction, the reaction mixture was concentrated and recrystallized in ethanol to obtain a product (6.16 g, 94%).

2) The product obtained from step 1) (6.16 g, 10 14.49 mmol), N-phenyl-2-naphthylamine (7.63 g, 34.78 mmol), sodium *tert*-butoxide (4.18 g, 43.4 mmol), Pd₂(dba)₃ (0.17 g, 0.29 mmol) and P(t-Bu)₃ (0.06 g, 0.29 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the 15 reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain a compound (6.0 g, 59%).

3) The compound obtained from step 2) (6.0 g, 8.54 mmol) was dissolved in trifluoroacetic acid/chloroform = 50 ml/50 ml and the solution was refluxed for 3 hours. The reaction mixture was cooled to room temperature, 25 quenched with aqueous NaOH solution, extracted with methylene chloride and then washed with water many times. The resultant product was dried over magnesium sulfate and allowed to evaporate. The crude product was purified by column chromatography (ethyl acetate/hexane = 1/9) to obtain a compound (3.8 g, 74%).

4) The product obtained from step 3) (3.8 g, 6.31 mmol), 4-bromophenyl-N-phenyl-2-naphthylamine (1.57 g,

4.21 mmol), $Pd_2(dba)_3$ (0.05 g, 0.084 mmol) and $P(t-Bu)_3$ (0.017 g, 0.084 mmol) and sodium tert-butoxide (1.21 g, 12.63 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of 5 the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over $MgSO_4$ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl 10 acetate/n-hexane to obtain the compound represented by formula 194 (1.2 g, 32%). MS[M+H] 895.

<Example 24> Preparation of the compound represented by formula 197

1) The compound represented by formula e (5.0 g, 15.38 mmol) and di-tert-butyl-dicarbonate (5.04 g, 23.08 mmol) were dissolved in 50 ml of THF and 4-(dimethylamino)pyridine (0.19 g, 1.54 mmol) was added thereto. Then, the reaction mixture was reacted at room temperature for 24 hours. After the completion of the 20 reaction, the reaction mixture was concentrated and recrystallized in ethanol to obtain a product (6.16 g, 94%).

2) The product obtained from step 1) (6.16 g, 14.49 mmol), 3-methyl-diphenylamine (6.37 g, 34.78 mmol), sodium tert-butoxide (4.18 g, 43.47 mmol), $Pd_2(dba)_3$ (0.17 g, 0.29 mmol) and $P(t-Bu)_3$ (0.06 g, 0.29 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the 30 reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over $MgSO_4$ and then concentrated. The resultant product was purified by

column chromatography and recrystallized in ethyl acetate/n-hexane to obtain a compound (6.3 g, 69%).

3) The compound obtained from step 2) (6.3 g, 10.0 mmol) was dissolved in trifluoroacetic acid/chloroform = 5 50 ml/50 ml and the solution was refluxed for 3 hours. The reaction mixture was cooled to room temperature, quenched with aqueous NaOH solution, extracted with methylene chloride and then washed with water many times. The resultant product was dried over magnesium 10 sulfate and allowed to evaporate. The crude product was purified by column chromatography (ethyl acetate/hexane = 1/9) to obtain a compound (3.8 g, 71%).

4) The product obtained from step 3) (3.8 g, 7.17 mmol), 4-bromophenyl-(3-methyl)-diphenylamine (1.42 g, 15 4.21 mmol), $Pd_2(dba)_3$ (0.05 g, 0.084 mmol) and $P(t-Bu)_3$ (0.017 g, 0.084 mmol) and sodium tert-butoxide (1.21 g, 12.63 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of 20 the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over $MgSO_4$ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by 25 formula 197 (1.2 g, 36%). MS [M+H] 787.

<Example 25> Preparation of the compound represented by formula 218

1) The compound represented by formula e (5.0 g, 15.38 mmol) and di-tert-butyl-dicarbonate (5.04 g, 23.08 30 mmol) were dissolved in 50 ml of THF and 4-(dimethylamino)pyridine (0.19 g, 1.54 mmol) was added thereto. Then, the reaction mixture was reacted at room

temperature for 24 hours. After the completion of the reaction, the reaction mixture was concentrated and recrystallized in ethanol to obtain a product (6.16 g, 94%).

5 2) The product obtained from step 1) (6.16 g, 14.49 mmol), diphenylamine (5.89 g, 34.78 mmol), sodium tert-butoxide (4.18 g, 43.47 mmol), $\text{Pd}_2(\text{dba})_3$ (0.17 g, 0.29 mmol) and $\text{P}(\text{t-Bu})_3$ (0.06 g, 0.29 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3
10 hours. After the completion of the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over MgSO_4 and then concentrated. The resultant product was purified by
15 column chromatography and recrystallized in ethyl acetate/n-hexane to obtain a compound (5.88 g, 67%).

3) The compound obtained from step 2) (5.88 g, 9.77 mmol) was dissolved in trifluoroacetic acid/chloroform = 50 ml/50 ml and the solution was
20 refluxed for 3 hours. The reaction mixture was cooled to room temperature, quenched with aqueous NaOH solution, extracted with methylene chloride and then washed with water many times. The resultant product was dried over magnesium sulfate and allowed to evaporate. The crude
25 product was purified by column chromatography (ethyl acetate/hexane = 1/9) to obtain a compound (2.9 g, 59%).

4) The product obtained from step 3) (2.9 g, 57.8 mmol), 4-bromophenyl-N-phenyl-1-naphthylamine (1.57 g, 4.21 mmol), $\text{Pd}_2(\text{dba})_3$ (0.05 g, 0.084 mmol) and $\text{P}(\text{t-Bu})_3$ (0.017 g, 0.084 mmol) and sodium tert-butoxide (1.21 g, 12.63 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of

the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by 5 column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 218 (1.5 g, 49%). MS [M+H] 795.

<Example 26> Preparation of the compound represented by formula 219

10 1) The compound represented by formula e (5.0 g, 15.38 mmol) and di-tert-butyl-dicarbonate (5.04 g, 23.08 mmol) were dissolved in 50 ml of THF and 4-(dimethylamino)pyridine (0.19 g, 1.54 mmol) was added thereto. Then, the reaction mixture was reacted at room 15 temperature for 24 hours. After the completion of the reaction, the reaction mixture was concentrated and recrystallized in ethanol to obtain a product (6.16 g, 94%).

2) The product obtained from step 1) (6.16 g, 20 14.49 mmol), N-phenyl-2-naphthylamine (7.63 g, 34.78 mmol), sodium tert-butoxide (4.18 g, 43.47 mmol), Pd₂(dba)₃ (0.17 g, 0.29 mmol) and P(t-Bu)₃ (0.06 g, 0.29 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of the 25 reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H₂O. The organic layer was separated, dried over MgSO₄ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain a compound (6.0 g, 59%).

3) The compound obtained from step 2) (6.0 g, 8.54 mmol) was dissolved in trifluoroacetic acid/chloroform =

50 ml/50 ml and the solution was refluxed for 3 hours. The reaction mixture was cooled to room temperature, quenched with aqueous NaOH solution, extracted with methylene chloride and then washed with water many 5 times. The resultant product was dried over magnesium sulfate and allowed to evaporate. The crude product was purified by column chromatography (ethyl acetate/hexane = 1/9) to obtain a compound (3.8 g, 74%).

4) The product obtained from step 3) (3.8 g, 6.31 10 mmol), 4-bromophenyl-N-phenyl-1-naphthylamine (1.57 g, 4.21 mmol), $Pd_2(dba)_3$ (0.05 g, 0.084 mmol) and $P(t-Bu)_3$ (0.017 g, 0.084 mmol) and sodium tert-butoxide (1.21 g, 12.63 mmol) were added to xylene (30 ml) and the mixture was refluxed for about 3 hours. After the completion of 15 the reaction, the reaction mixture was cooled to room temperature and added to a mixed solution of THF and H_2O . The organic layer was separated, dried over $MgSO_4$ and then concentrated. The resultant product was purified by column chromatography and recrystallized in ethyl 20 acetate/n-hexane to obtain the compound represented by formula 219 (1.2 g, 32%). MS[M+H] 895.

<Example 27> Preparation of the compound represented by formula 252

25 The compound represented by formula c (1.00 g, 2.08 mmol), triphenylamine-4-boronic acid (1.99 g, 6.87 mmol), 2M potassium carbonate solution (10 ml) and tetrakis(triphenylphosphine) palladium (0.07 g, 0.06 mmol) were added to 40 ml of THF. The mixture was stirred under reflux for about 24 hours and then cooled 30 to room temperature. The reaction mixture was added to toluene/brine, and then the toluene layer was separated, dried over $MgSO_4$, filtered and concentrated. The

resultant product was purified by column chromatography and recrystallized in ethyl acetate/n-hexane to obtain the compound represented by formula 252 (1.15 g, 55%). ^1H NMR (300 MHz, CDCl_3) 6.76-6.82(m, 18H), 6.92-6.95(m, 6H), 5 7.31-7.35(m, 12H), 7.53-7.60(m, 10H), 7.76-8.07(m, 6H); MS [M+H] 973.

<Example 28> Manufacture of organic light emitting device

A glass substrate on which a thin film of ITO (indium tin oxide) was coated to a thickness of 1000Å 10 was immersed in distilled water containing a detergent to wash the substrate with ultrasonic waves. The detergent was a product commercially available from Fisher Co. The distilled water has been filtered twice 15 by using a filter commercially available from Millipore Co. After washing ITO for 30 minutes, washing with ultrasonic waves was repeated twice for 10 minutes by using distilled water. After the completion of washing with distilled water, washing with ultrasonic waves was 20 carried out by using isopropyl alcohol, acetone and methanol, in turn. The resultant substrate was dried and transferred to a plasma cleaner. Then, the substrate was cleaned for 5 minutes by using oxygen plasma and transferred to a vacuum deposition device.

25 On the ITO transparent electrode (first electrode) prepared as described above, the compound represented by the above formula 61 was coated to a thickness of 600Å by thermal vacuum deposition, thereby forming a hole injection layer. Next, NPB as a hole transport material 30 was coated thereon to a thickness of 400Å by vacuum deposition. Additionally, Alq₃, which serves as light emitting/electron injection/electron transport material

was coated thereon to a thickness of 500Å by vacuum deposition to complete the formation of a thin film of organic materials. On the Alq3 layer, lithium fluoride (LiF) and aluminum were sequentially vacuum-deposited to 5 a thickness of 15Å and 2500Å, respectively, to form a cathode (second electrode). In the above process, deposition rate of each organic material was maintained at 0.5-1.0 Å/sec and deposition rates of lithium fluoride and aluminum were maintained at 0.2 Å/sec and 10 2-3 Å/sec, respectively.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.87 cd/A under the application of a forward electric field with a drive voltage of 7.17V at a current density of 100 mA/cm².

15 **<Example 29> Manufacture of organic light emitting device**

On the ITO transparent electrode prepared as described in Example 28, the compound represented by the above formula 62 was coated to a thickness of 800Å by 20 thermal vacuum deposition, thereby forming a hole injection layer. Next, NPB as a hole transport material was coated thereon to a thickness of 400Å by vacuum deposition. Additionally, Alq3, which serves as light emitting/electron injection/electron transport material 25 was coated thereon to a thickness of 300Å by vacuum deposition to complete the formation of a thin film of organic materials. The remaining procedure was the same as Example 28.

The resultant organic electroluminescence device 30 showed a spectrum having a luminance of 3.86 cd/A under the application of a forward electric field with a drive voltage of 7.8V at a current density of 100 mA/cm².

<Example 30> Manufacture of organic light emitting device

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound 5 represented by the above formula 63 was used instead of the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.8 cd/A under the application of a forward electric field with a drive 10 voltage of 7.8V at a current density of 100 mA/cm².

<Example 31> Manufacture of organic light emitting device

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound 15 represented by the above formula 64 was used instead of the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.61 cd/A under the application of a forward electric field with a drive 20 voltage of 8.1V at a current density of 100 mA/cm².

<Example 32> Manufacture of organic light emitting device

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound 25 represented by the above formula 69 was used instead of the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.82 cd/A under the application of a forward electric field with a drive 30 voltage of 8.0V at a current density of 100 mA/cm².

<Example 33> Manufacture of organic light emitting device

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound represented by the above formula 71 was used instead of the compound represented by the above formula 61.

5 The resultant organic electroluminescence device showed a spectrum having a luminance of 4.4 cd/A under the application of a forward electric field with a drive voltage of 7.6V at a current density of 100 mA/cm².

10 **<Example 34> Manufacture of organic light emitting device**

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound represented by the above formula 72 was used instead of the compound represented by the above formula 61.

15 The resultant organic electroluminescence device showed a spectrum having a luminance of 4.15 cd/A under the application of a forward electric field with a drive voltage of 7.8V at a current density of 100 mA/cm².

20 **<Example 35> Manufacture of organic light emitting device**

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound represented by the above formula 89 was used instead of the compound represented by the above formula 61.

25 The resultant organic electroluminescence device showed a spectrum having a luminance of 4.3 cd/A under the application of a forward electric field with a drive voltage of 7.5 at a current density of 100 mA/cm².

30 **<Example 36> Manufacture of organic light emitting device**

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound

represented by the above formula 95 was used instead of the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 4.5 cd/A under 5 the application of a forward electric field with a drive voltage of 7.3V at a current density of 100 mA/cm².

<Example 37> Manufacture of organic light emitting device

Example 28 was repeated to manufacture an organic 10 electroluminescence device, except that the compound represented by the above formula 96 was used instead of the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 4.4 cd/A under 15 the application of a forward electric field with a drive voltage of 7.2V at a current density of 100 mA/cm².

<Example 38> Manufacture of organic light emitting device

Example 28 was repeated to manufacture an organic 20 electroluminescence device, except that the compound represented by the above formula 113 was used instead of the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 4.2 cd/A under 25 the application of a forward electric field with a drive voltage of 7.7V at a current density of 100 mA/cm².

<Example 39> Manufacture of organic light emitting device

Example 28 was repeated to manufacture an organic 30 electroluminescence device, except that the compound represented by the above formula 114 was used instead of the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 4.1 cd/A under the application of a forward electric field with a drive voltage of 7.6V at a current density of 100 mA/cm².

5 **<Example 40> Manufacture of organic light emitting device**

Example 28 was repeated to manufacture an organic electroluminescence device, except that the compound represented by the above formula 120 was used instead of 10 the compound represented by the above formula 61.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.98 cd/A under the application of a forward electric field with a drive voltage of 7.8V at a current density of 100 mA/cm².

15 **<Example 41> Manufacture of organic light emitting device**

On the ITO transparent electrode prepared as described in Example 28, the compound represented by the above formula 192 was coated to a thickness of 800Å by 20 thermal vacuum deposition, thereby forming a hole injection layer. Next, NPB as a hole transport material was coated thereon to a thickness of 300Å by vacuum deposition. Additionally, Alq₃, which serves as light emitting/electron injection/electron transport material 25 was coated thereon to a thickness of 300Å by vacuum deposition to complete the formation of a thin film of organic materials. The remaining procedure was the same as Example 28.

The resultant organic electroluminescence device 30 showed a spectrum having a luminance of 3.7 cd/A under the application of a forward electric field with a drive voltage of 6.7V at a current density of 100 mA/cm².

<Example 42> Manufacture of organic light emitting device

Example 41 was repeated to manufacture an organic electroluminescence device, except that the compound 5 represented by the above formula 193 was used instead of the compound represented by the above formula 192.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.6 cd/A under the application of a forward electric field with a drive 10 voltage of 6.9V at a current density of 100 mA/cm².

<Example 43> Manufacture of organic light emitting device

Example 41 was repeated to manufacture an organic electroluminescence device, except that the compound 15 represented by the above formula 194 was used instead of the compound represented by the above formula 192.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.5 cd/A under the application of a forward electric field with a drive 20 voltage of 6.8V at a current density of 100 mA/cm².

<Example 44> Manufacture of organic light emitting device

Example 41 was repeated to manufacture an organic electroluminescence device, except that the compound 25 represented by the above formula 197 was used instead of the compound represented by the above formula 192.

The resultant organic electroluminescence device showed a spectrum having a luminance of 3.9 cd/A under the application of a forward electric field with a drive 30 voltage of 6.9V at a current density of 100 mA/cm².

<Example 45> Manufacture of organic light emitting device

Example 41 was repeated to manufacture an organic electroluminescence device, except that the compound represented by the above formula 218 was used instead of the compound represented by the above formula 192.

5 The resultant organic electroluminescence device showed a spectrum having a luminance of 3.8 cd/A under the application of a forward electric field with a drive voltage of 6.8V at a current density of 100 mA/cm².

10 <Example 46> Manufacture of organic light emitting device

Example 41 was repeated to manufacture an organic electroluminescence device, except that the compound represented by the above formula 219 was used instead of the compound represented by the above formula 192.

15 The resultant organic electroluminescence device showed a spectrum having a luminance of 3.6 cd/A under the application of a forward electric field with a drive voltage of 6.8V at a current density of 100 mA/cm².

20 <Example 47> Manufacture of organic light emitting device

Example 41 was repeated to manufacture an organic electroluminescence device, except that the compound represented by the above formula 252 was used instead of the compound represented by the above formula 192.

25 The resultant organic electroluminescence device showed a spectrum having a luminance of 3.2 cd/A under the application of a forward electric field with a drive voltage of 6.88V at a current density of 100 mA/cm².

30 As can be seen from the above Examples, the organic electroluminescence device using the compound according to the present invention as a hole injection

material can provide excellent electroluminescence effect as demonstrated by a luminance of 3.2-4.5 cd/A under a forward electric field of about 6.88V at a current density of 100 mA/cm². In other words, when the 5 compound according to the present invention is used as hole injection material in an organic electroluminescence device comprising NPB as hole transport material and Alq₃ as light emitting/electron injection/electron transport material, it is possible to 10 improve electroluminescence effect significantly compared to conventional devices.

Industrial Applicability

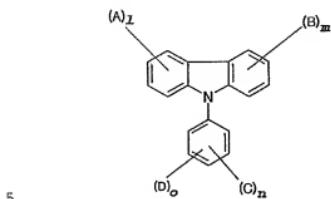
As can be seen from the foregoing, novel compounds 15 according to the present invention can realize improvements in luminous efficiency and lifespan, when they are used in organic compound layers of an organic electroluminescence (EL) device, which is one of light emitting devices. Therefore, the compound according to 20 the present invention can be advantageously used in the field of electric devices including organic light emitting devices.

Claims

1. A compound represented by the following formula

1:

【formula 1】



wherein A is $-\text{[R1}-\overset{\text{R2}}{\underset{|}{\text{N}}}-]$ or $-\text{[R1}-\overset{\text{R2}}{\underset{|}{\text{N}}}-\text{Ar}-]$;

B is $-\text{[R3}-\overset{\text{R4}}{\underset{|}{\text{N}}}-]$ or $-\text{[R3}-\overset{\text{R4}}{\underset{|}{\text{N}}}-\text{Ar}-]$;

C is $-\text{[R5}-\overset{\text{R6}}{\underset{|}{\text{N}}}-]$ or $-\text{[R5}-\overset{\text{R6}}{\underset{|}{\text{N}}}-\text{Ar}-]$;

D is H, $-\text{[R7}-\overset{\text{R8}}{\underset{|}{\text{N}}}-]$ or $-\text{[R9}-\overset{\text{R10}}{\underset{|}{\text{N}}}-\text{Ar}-]$;

10 R1 to R10 are the same or different and each comprises, only once or repeatedly at least two times, at least one selected from the group consisting of a hydrogen atom; aliphatic hydrocarbon having 1-20 carbon atoms; aromatic hydrocarbon non-substituted or
 15 substituted with a nitro, nitrile, halogen, alkyl, alkoxy or amino group; silicon group having an aromatic substituent; heterocyclic aromatic hydrocarbon non-substituted or substituted with a nitro, nitrile, halogen, alkyl, alkoxy or amino group; thiophene group substituted with a C1-C20 hydrocarbon or C6-C24 aromatic hydrocarbon; and a boron group substituted with an aromatic hydrocarbon;

Ar is an aromatic hydrocarbon non-substituted or substituted with a nitro, nitrile, halogen, alkyl, alkoxy or amino group; and

each of l, m and n is an integer of 1 or more and
5 o is an integer of 0 or more;

with the proviso that the compound represented by formula 1 wherein R1, R2, R3, R4, R5 and R6 represent hydrogen atoms simultaneously and D is also a hydrogen atom is excluded.

10

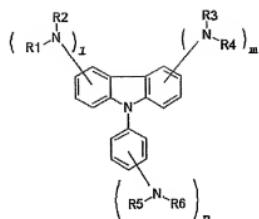
2. The compound according to claim 1, wherein the aromatic hydrocarbon includes phenyl, biphenyl, terphenyl, naphthyl, anthracenyl, phenanthrene, pyrenyl and perylenyl.

15

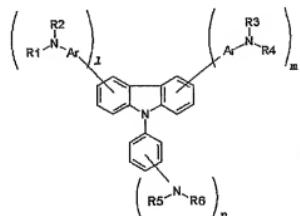
3. The compound according to claim 1, wherein the heteroaromatic hydrocarbon includes thiophene, furan, pyrrole, imidazole, thiazole, oxazole, oxadiazole, thiadiazole, triazole, pyridyl, pyridazyl, pyrazine, 20 quinoline and isoquinoline.

4. The compound according to claim 1, wherein the compound is represented by any one formula selected from the group consisting of the following formulae 2a-2e:

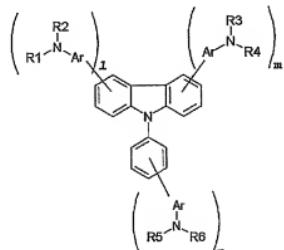
25 [formula 2a]



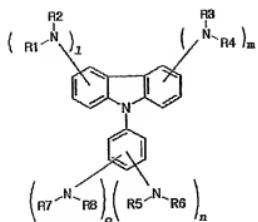
[formula 2b]



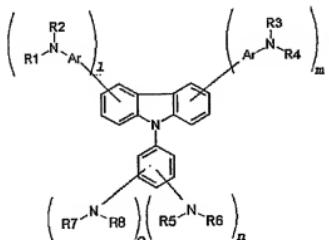
[formula 2c]



[formula 2d]



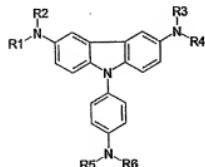
【formula 2e】



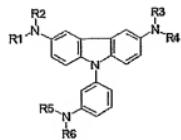
wherein each of l, m, n, o and R1-R8 is the same as
5 defined in claim 1.

5. The compound according to claim 1, wherein the compound is represented by any one formula selected from the following formulae 3a-3n:

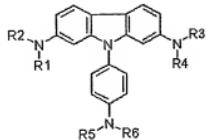
10 【formula 3a】



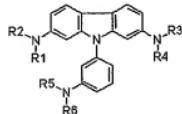
【formula 3b】



[formula 3c]

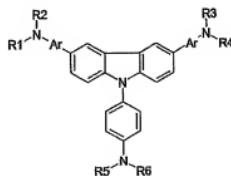


[formula 3d]

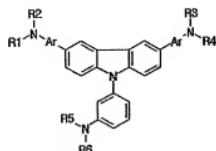


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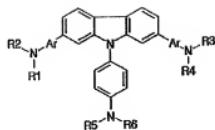
[formula 3e]



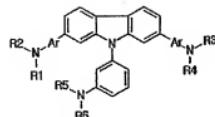
[formula 3f]



10 [formula 3g]

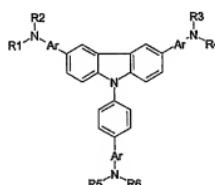


[formula 3h]

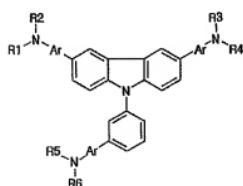


[formula 3i]

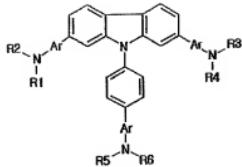
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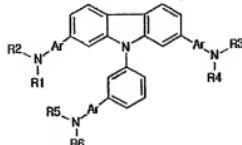
[formula 3j]



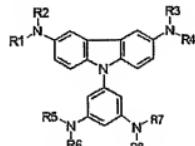
10 [formula 3k]



[formula 31]

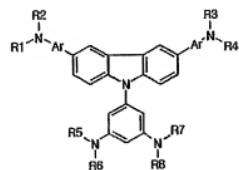


[formula 3m]



5

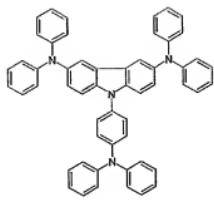
[formula 3n]



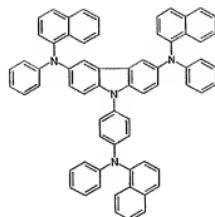
wherein each of R1-R8 is the same as defined in
claim 1.

10

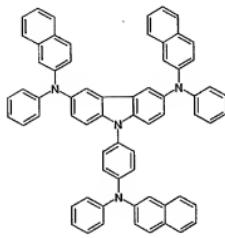
6. The compound according to claim 1, wherein the compound represented by formula 1 is any one of compounds represented by the following formulae 61-227:



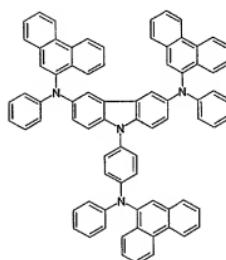
formula 61



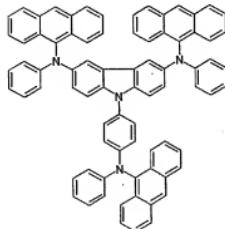
formula 62



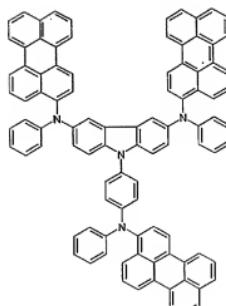
formula 63



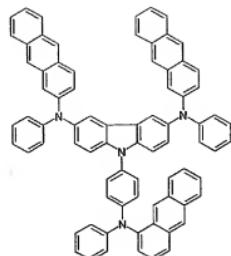
formula 64



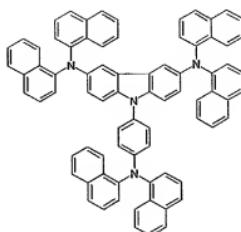
formula 65



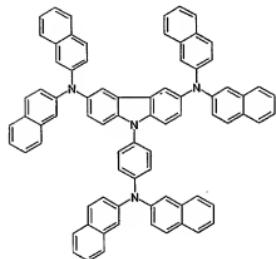
formula 66



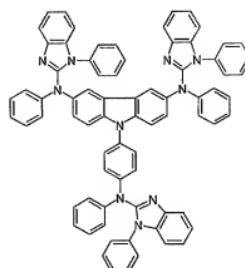
formula 67



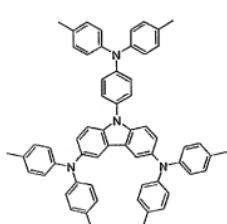
formula 68



formula 69

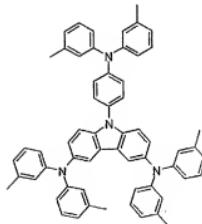


formula 70

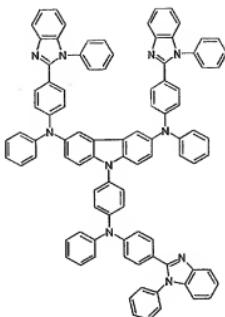


5

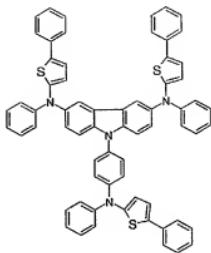
formula 71



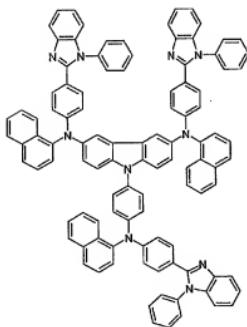
formula 72



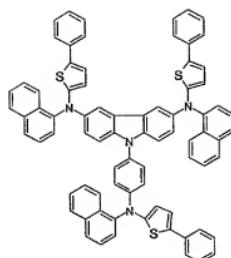
formula 73



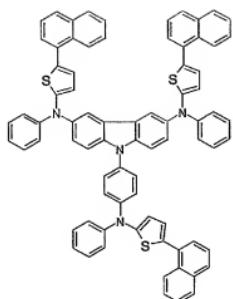
formula 74



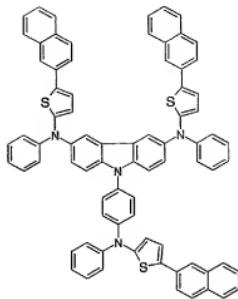
formula 75



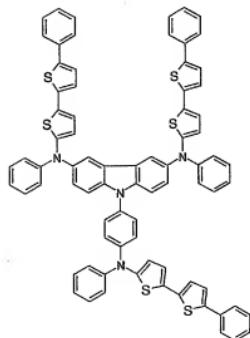
formula 76



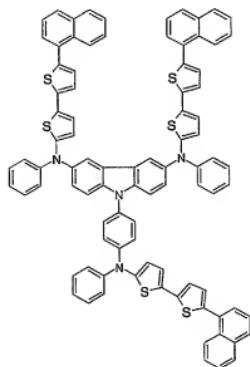
formula 77



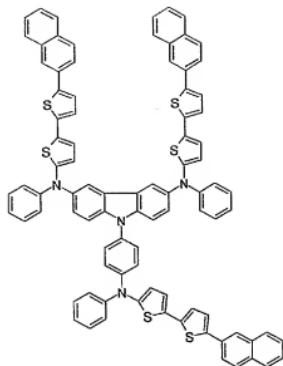
formula 78



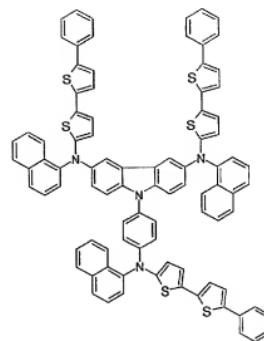
formula 79



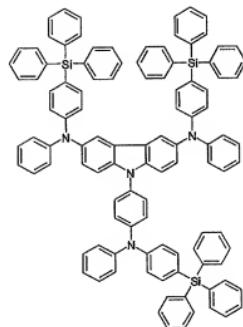
formula 80



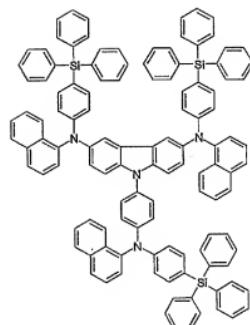
formula 81



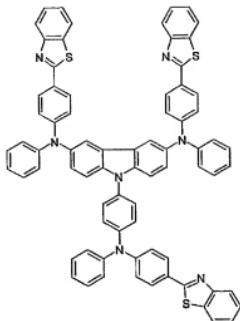
formula 82



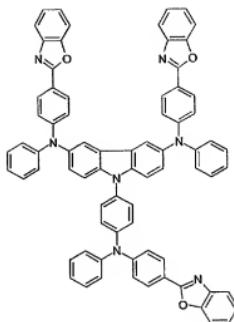
formula 83



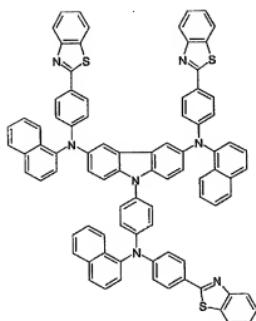
formula 84



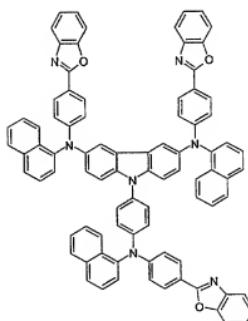
formula 85



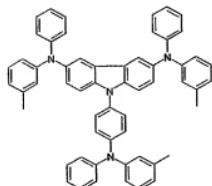
formula 86



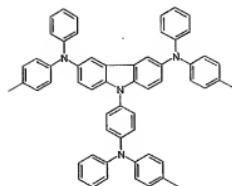
formula 87



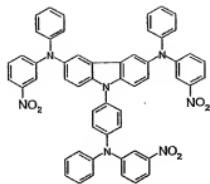
formula 88



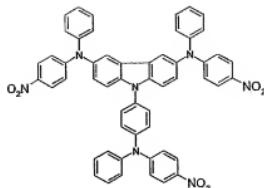
formula 89



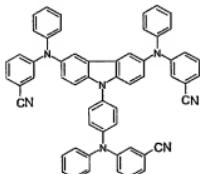
formula 90



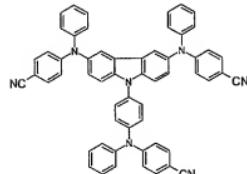
formula 91



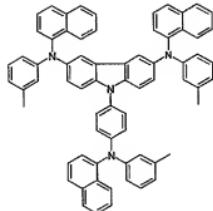
formula 92



formula 93

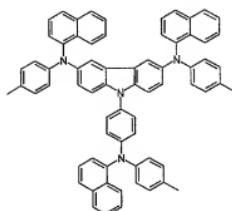


formula 94

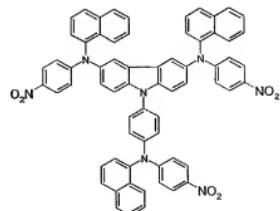
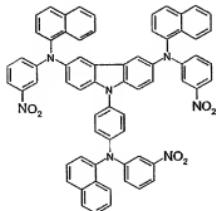


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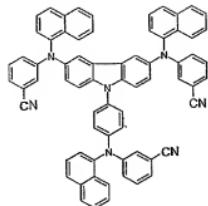
formula 95



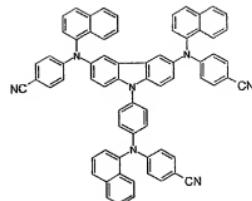
formula 96



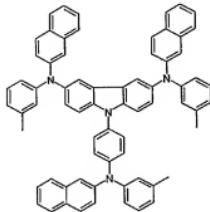
formula 97



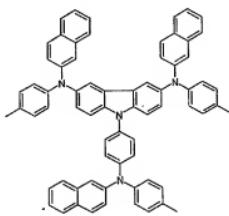
formula 98



formula 99

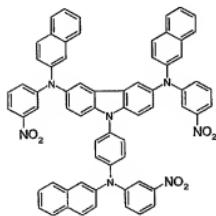


formula 100

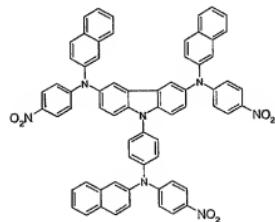


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formula 101

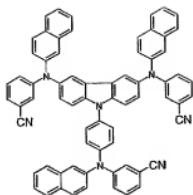


formula 102

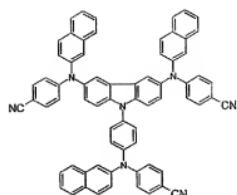


formula 103

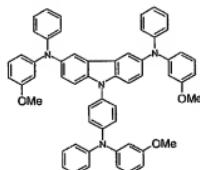
formula 104



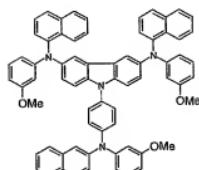
formula 105



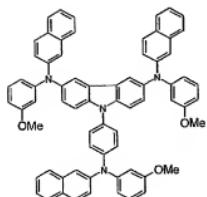
formula 106



formula 107

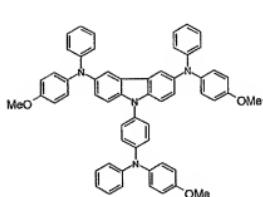


formula 108

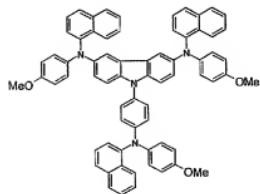


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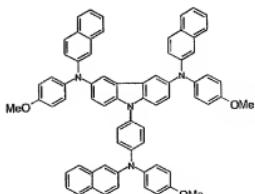
formula 109



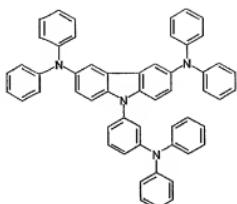
formula 110



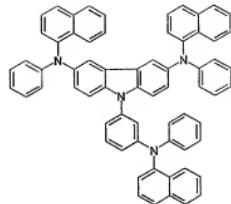
formula 111



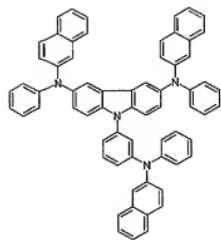
formula 112



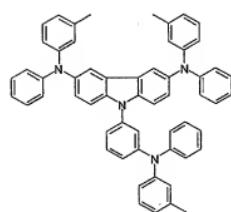
formula 113



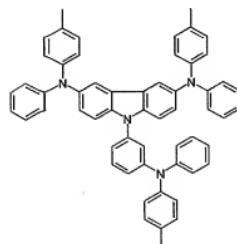
formula 114



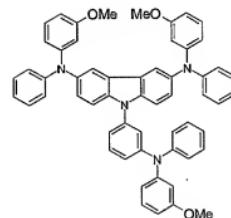
formula 115



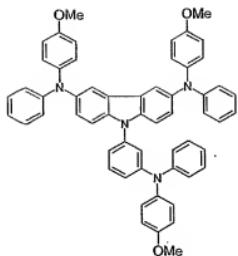
formula 116



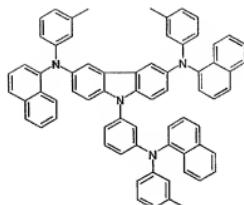
formula 117



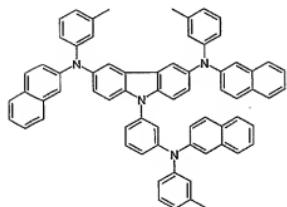
formula 118



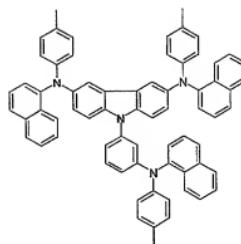
formula 119



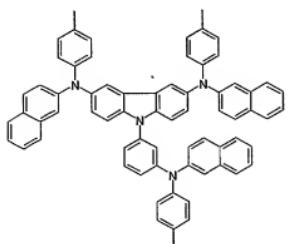
formula 120



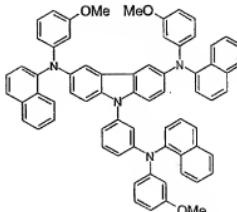
formula 121



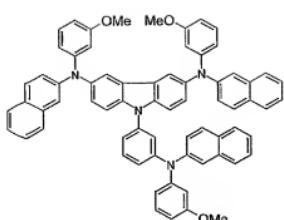
formula 122



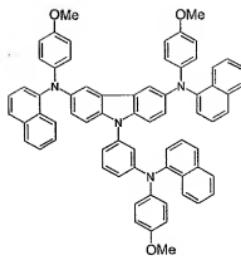
formula 123



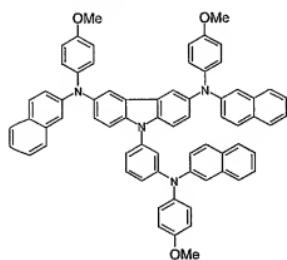
formula 124



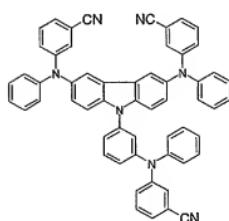
formula 125



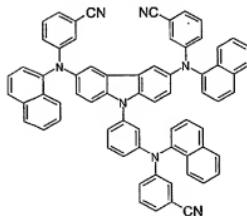
formula 126



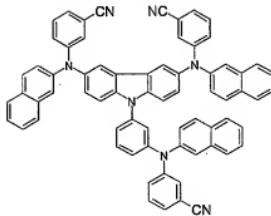
formula 127



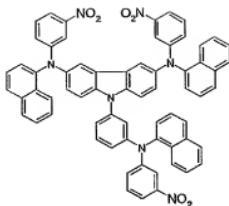
formula 128



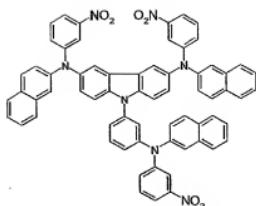
formula 129



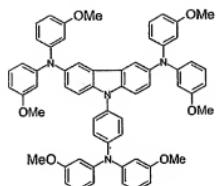
formula 130



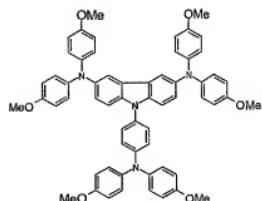
formula 131



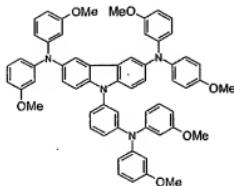
formula 132



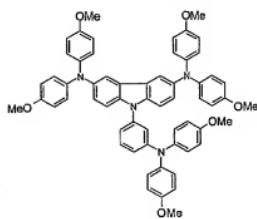
formula 133



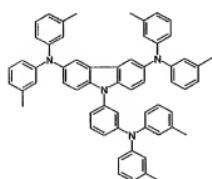
formula 134



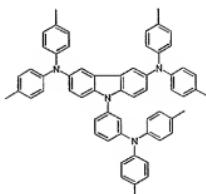
formula 135



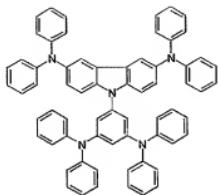
formula 136



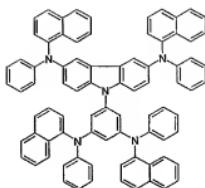
formula 137



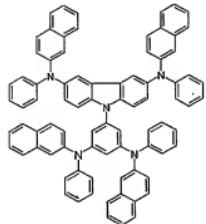
formula 138



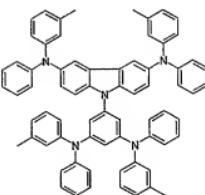
formula 139



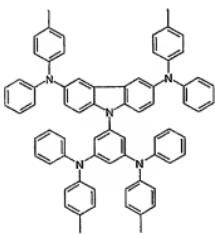
formula 140



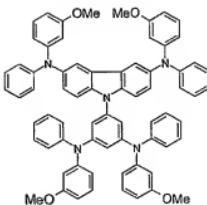
formula 141



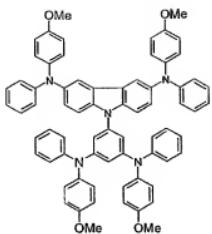
formula 142



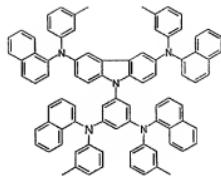
formula 143



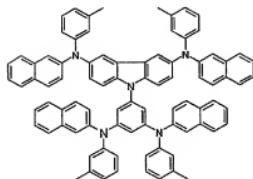
formula 144



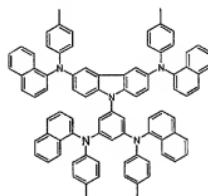
formula 145



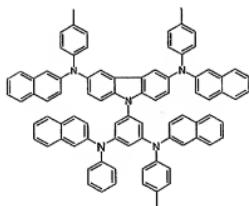
formula 146



formula 147

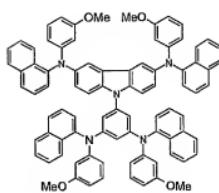


formula 148

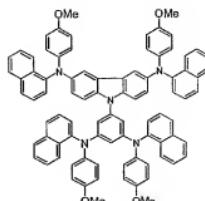
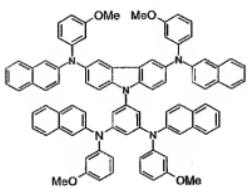


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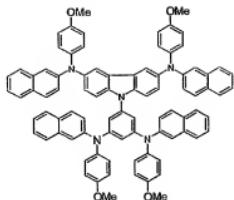
formula 149



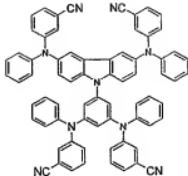
formula 150



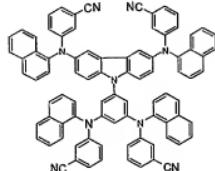
formula 151



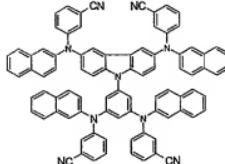
formula 152



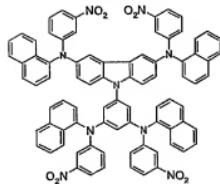
formula 153



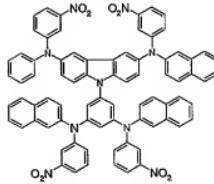
formula 154



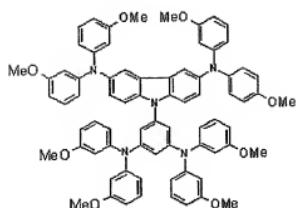
5 formula 155



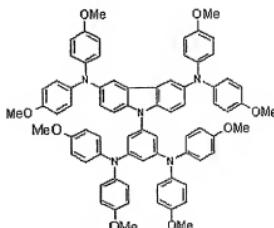
formula 156



formula 157

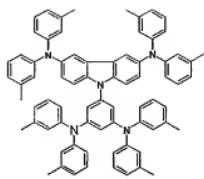


formula 158

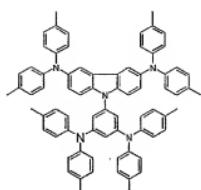


formula 159

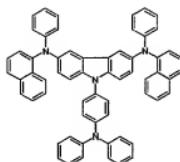
formula 160



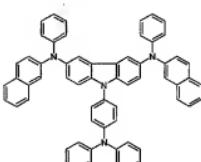
formula 161



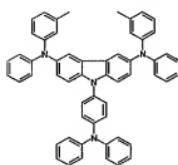
formula 162



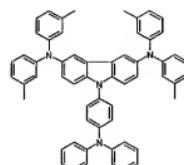
formula 163



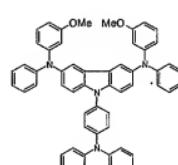
formula 164



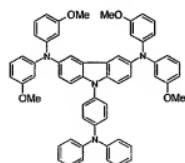
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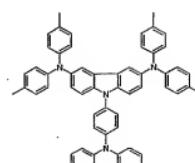
formula 166



formula 167

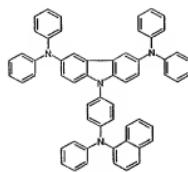


formula 168

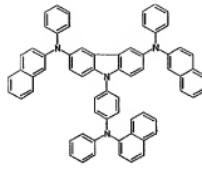


formula 169

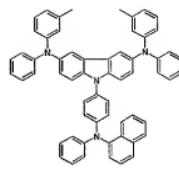
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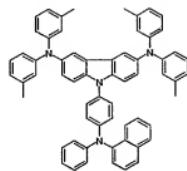
formula 170



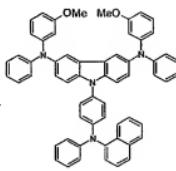
formula 171



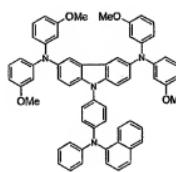
formula 172



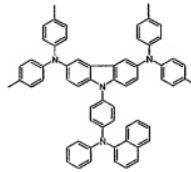
formula 173



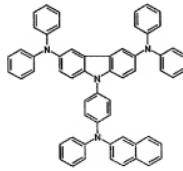
formula 174



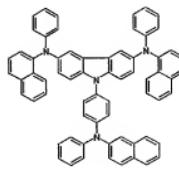
formula 175



formula 176

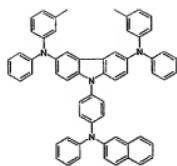


formula 177

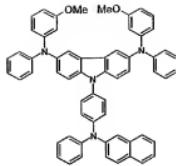


formula 178

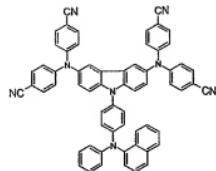
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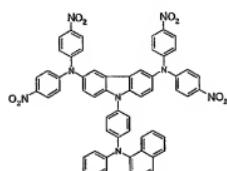
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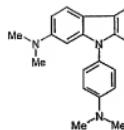
formula 180



formula 181

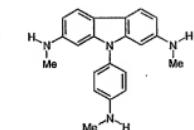


formula 182

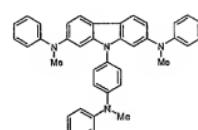


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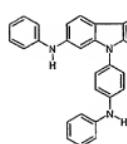
formula 183



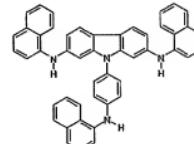
formula 184



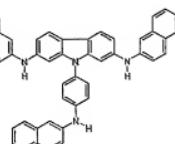
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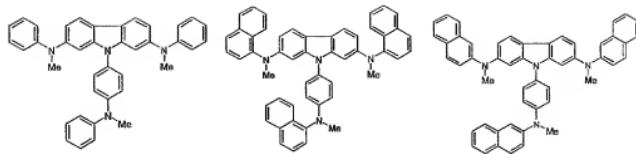
formula 186



formula 187



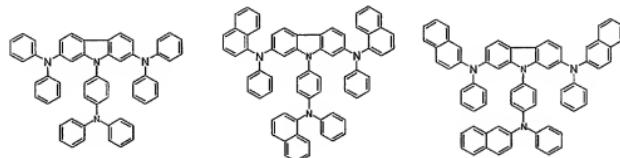
formula 188



formula 189

formula 190

formula 191

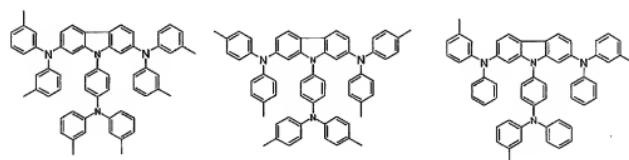


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formula 192

formula 193

formula 194

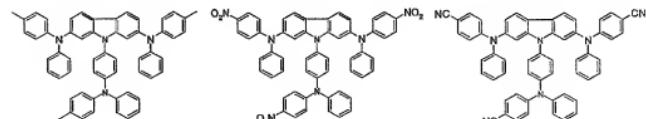


formula 195

formula 196

formula 197

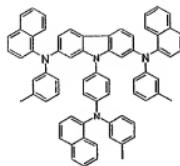
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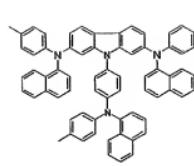
formula 198

formula 199

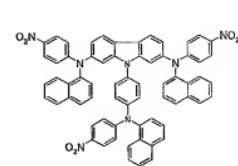
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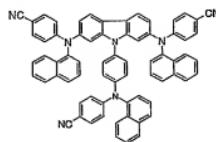
formula 201



formula 202

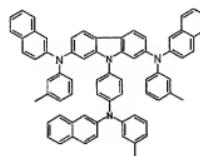


formula 203

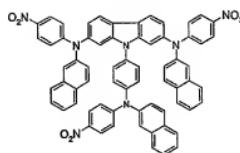


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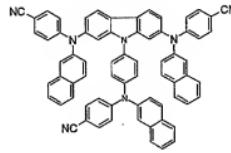
formula 204



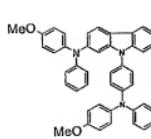
formula 205



formula 206

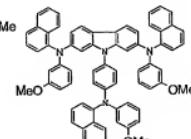


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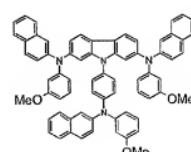


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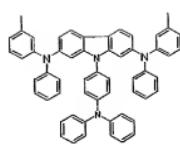
formula 208



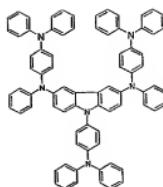
formula 209



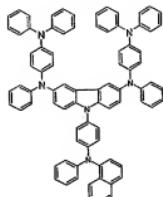
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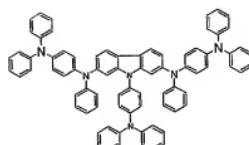
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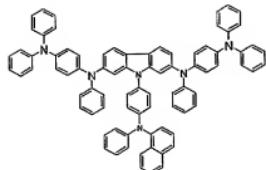
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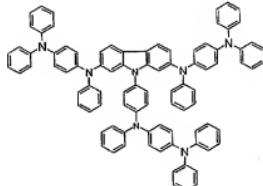
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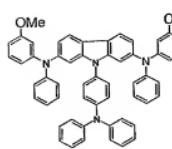
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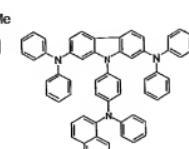
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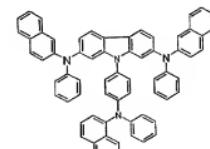
formula 216



formula 217

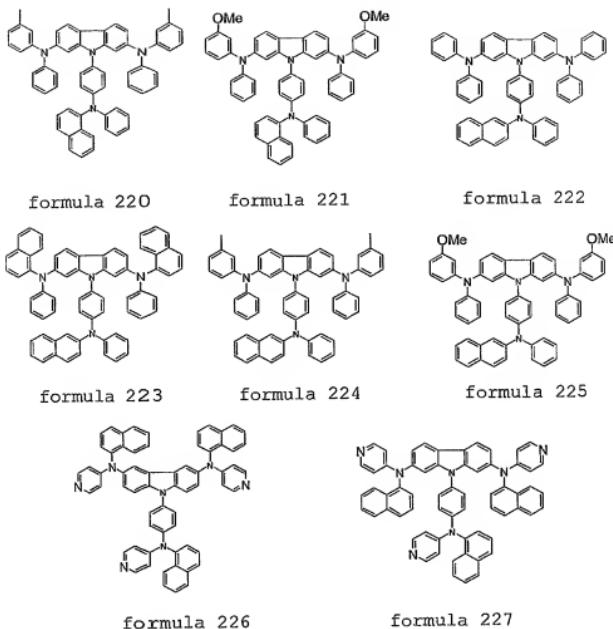


formula 218



formula 219

5



7. An organic light emitting device comprising a first electrode, a second electrode and one or more 10 organic compound layers disposed between both the electrodes, wherein at least one of the organic compound layers comprises at least one compound as defined in any one of claims 1 to 6.

15 8. The organic light emitting device according to
claim 7, wherein the organic compound layer comprising
at least one compound as defined in any one of claims 1
to 6 is a hole injection/hole transport layer having

hole injection and hole transport functions.

9. The organic light emitting device according to claim 7, wherein the organic compound layer comprising 5 at least one compound as defined in any one of claims 1 to 6 is a hole injection/hole transport/light emitting layer having hole injection, hole transport and light emitting functions.

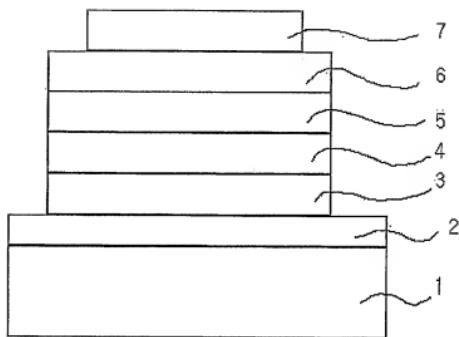
10 10. The organic light emitting device according to claim 7, wherein the organic compound layer comprising at least one compound as defined in any one of claims 1 to 6 is a hole injection layer having hole injection function.

15

11. The organic light emitting device according to claim 7, which comprises a substrate, anode, hole injection layer, hole transport layer, organic light emitting layer, electron transport layer and a cathode, 20 from the bottom, wherein the organic compound layer comprising at least one compound as defined in any one of claims 1 to 6 is at least one selected from the group consisting of the hole injection layer, hole transport layer and the light emitting layer.

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1/1

FIGURES**FIG. 1**

INTERNATIONAL SEARCH REPORT

International application No.
PCT/KR2005/000794

A. CLASSIFICATION OF SUBJECT MATTER

IPC7 C09K 11/06

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC7: C09K 11/06, B32B 9/00, C09K 11/02, GO3C 5/00, H01J 1/62, H05B 33/14

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

KR, JP: classes as above

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

JPA, NPS, ESPACENET, USPTO

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US06660410 B1 (Idemitsu Kosan Co.) 2003/12/09 see the whole document	1-11
A	US06451455 B1 (The Trustees of Princeton University) 2002/09/17 see the whole document	1-11
A	US05475213 B1 (Mitsubishi Chemical Co) 1995/12/12 see the whole document	1-11
A	US06696181 B1 (Hitachi, Ltd) 2004/02/24 see the whole document	1-11

 Further documents are listed in the continuation of Box C. See patent family annex.

* Special categories of cited documents:
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 "O" document referring to an oral disclosure, use, exhibition or other means
 "P" document published prior to the international filing date but later than the priority date claimed

"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
 "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
 "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
 "&#" document member of the same patent family

Date of the actual completion of the international search

25 MAY 2005 (25.05.2005)

Date of mailing of the international search report

26 MAY 2005 (26.05.2005)

Name and mailing address of the ISA/KR



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